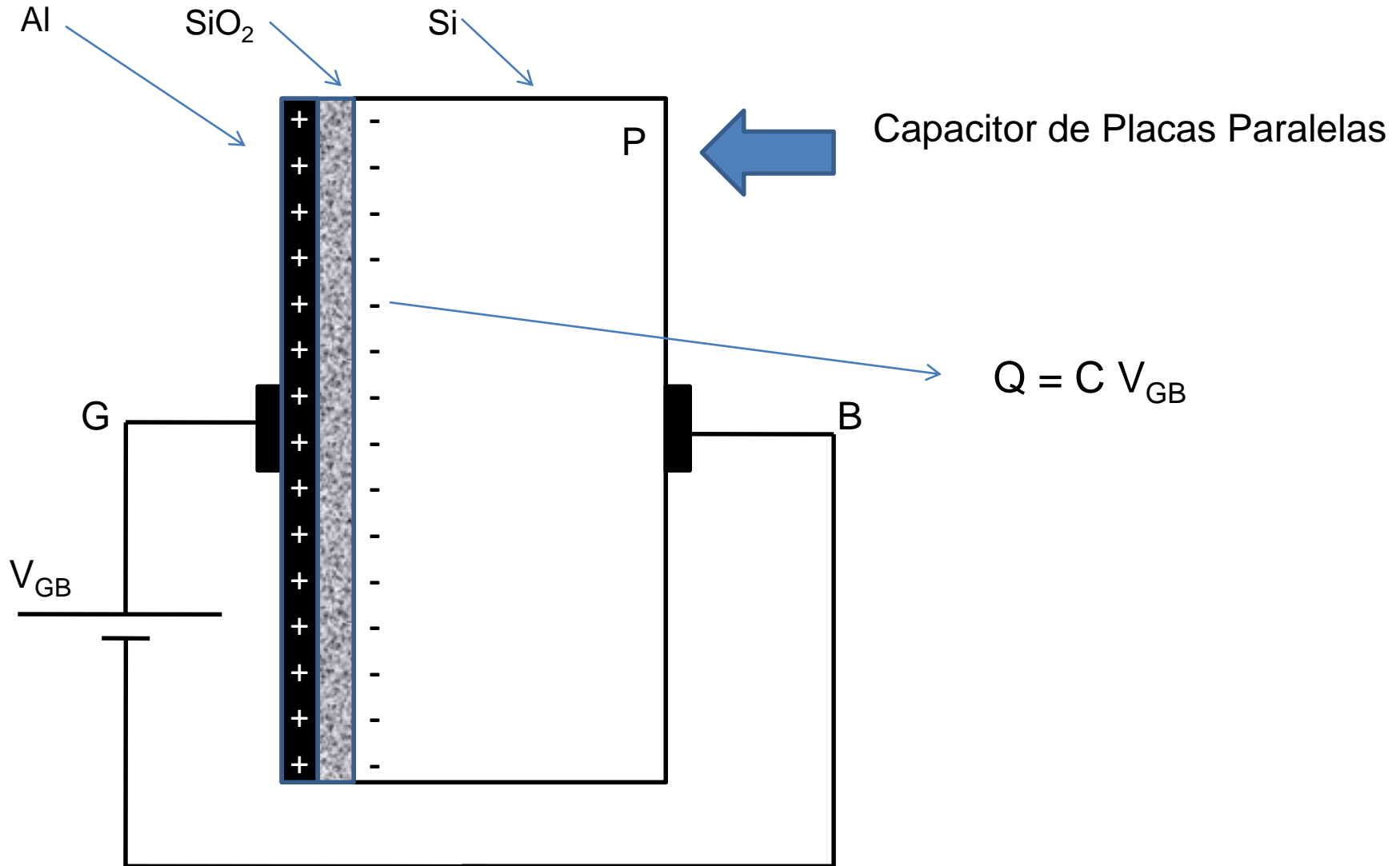
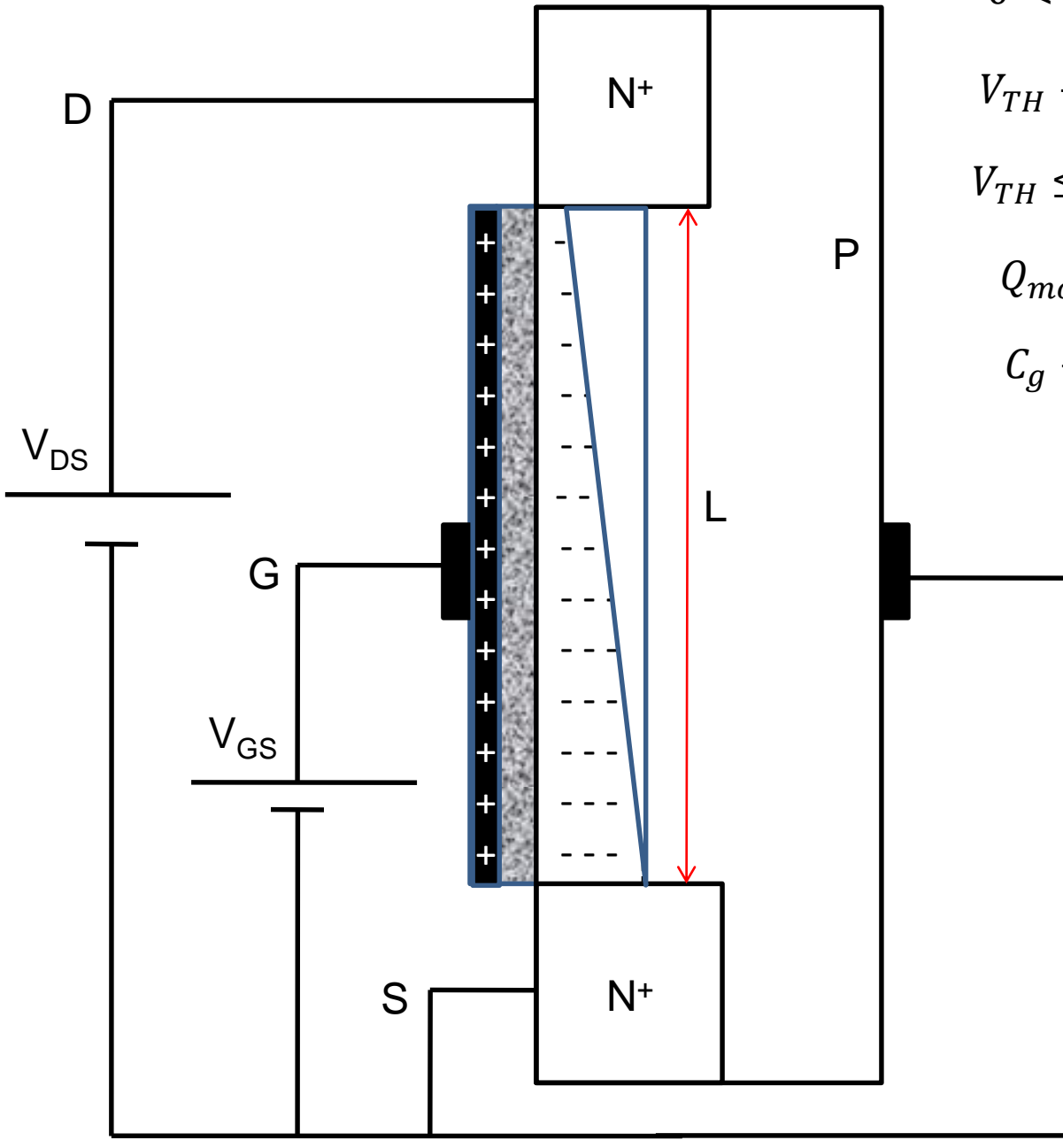


TRANSISTOR DE EFECTO DE CAMPO (FET)

METAL-OXIDO-SEMICONDUCTOR (MOSFET)





$$0 < V_{GS} < V_{TH} \rightarrow Q_{movil} = 0$$

$V_{TH} \rightarrow$ Tension umbral

$V_{TH} \leq V_{GS} \rightarrow$ Carga movil en el canal

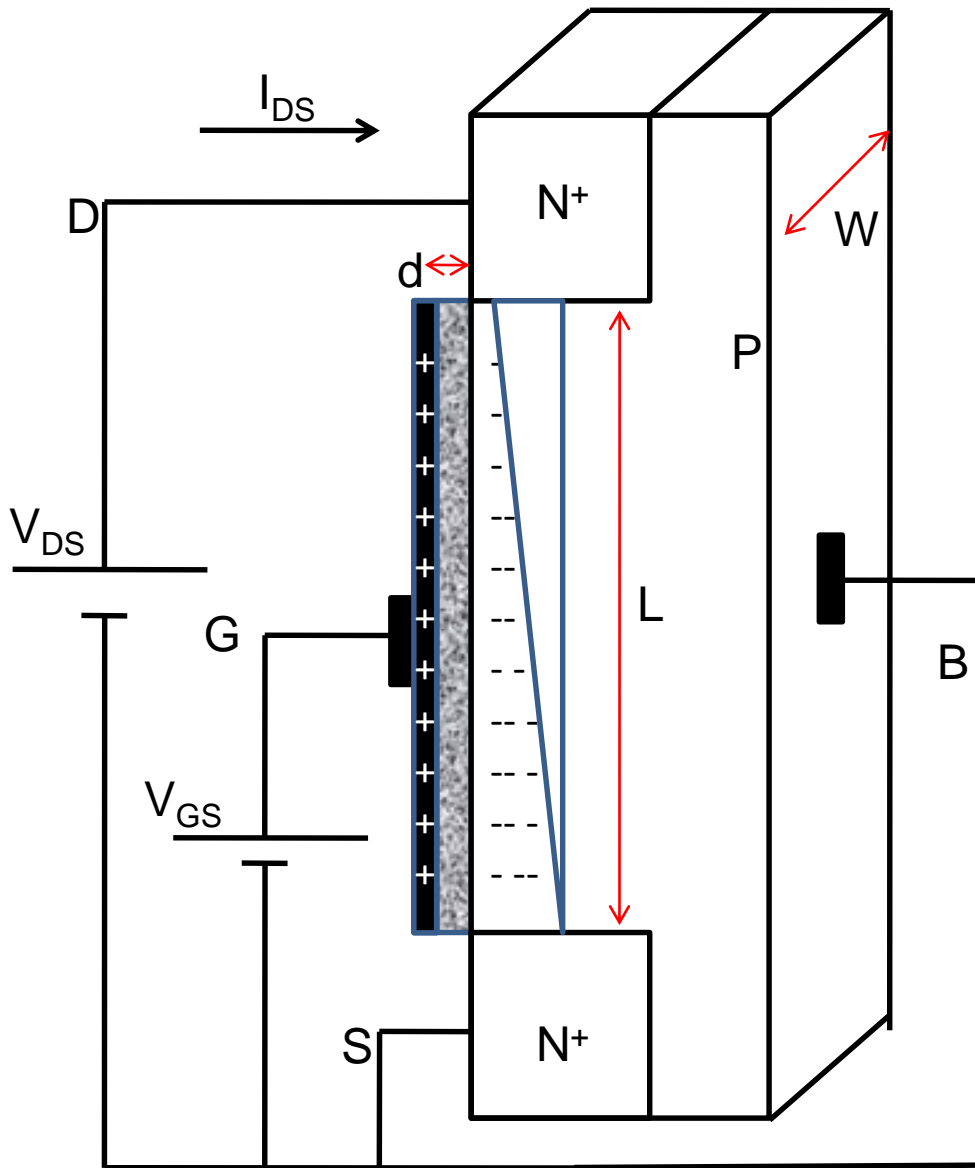
$$Q_{movil} = C_g (V_{GS} - V_{TH})$$

$C_g \rightarrow$ Capacidad de compuerta

$$C_g = \epsilon \frac{A}{d} = \epsilon \frac{W L}{d}$$

$$Q_{movil} = C_g \left(V_{GS} - V_{TH} - \frac{V_{DS}}{2} \right)$$

$$Q_{movil} = \epsilon \frac{W L}{d} \left(V_{GS} - V_{TH} - \frac{V_{DS}}{2} \right)$$



$$I_{DS} = \frac{\text{Carga movil en el canal}}{\text{Tiempo de Transito}}$$

$$I_{DS} = \frac{Q_{movil}}{T_T}$$

$$Q_{movil} = \varepsilon \frac{WL}{d} \left(V_{GS} - V_{TH} - \frac{V_{DS}}{2} \right)$$

$$T_T = \frac{L}{v_d} \quad v_d = \mu E \quad E = \frac{V_{DS}}{L}$$

$$T_T = \frac{L^2}{\mu V_{DS}}$$

$$I_{DS} = \frac{\mu \varepsilon W}{d} \frac{1}{L} \left(V_{GS} - V_{TH} - \frac{V_{DS}}{2} \right) V_{DS}$$

$$\frac{\mu \varepsilon W}{d} \frac{1}{L} \rightarrow \text{Depende de la fabricacion}$$

$$\beta = \frac{\mu \varepsilon W}{d} \frac{1}{L}$$

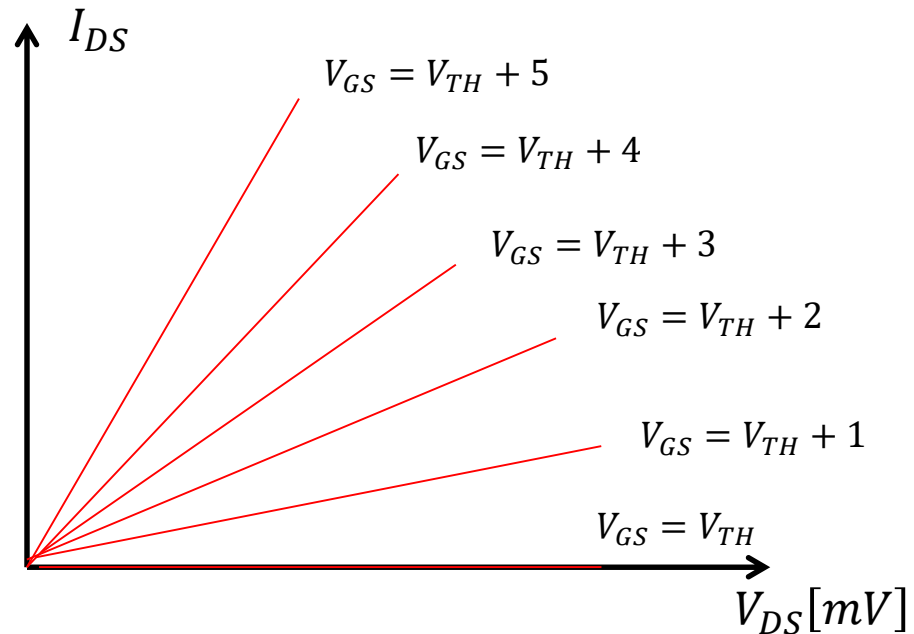
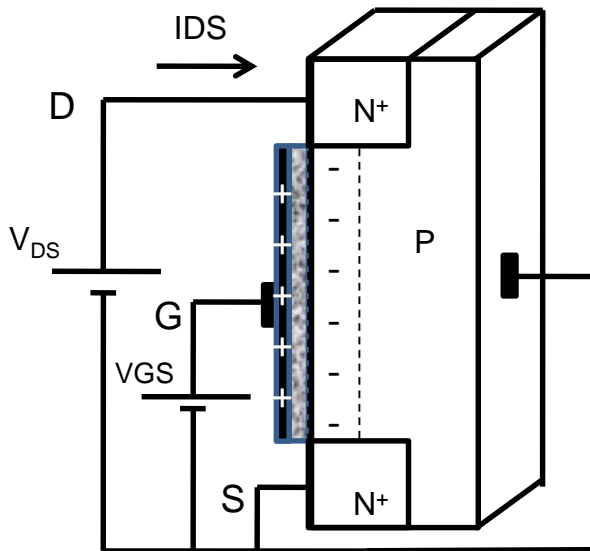
$$I_{DS} = \beta(V_{GS} - V_{TH})V_{DS} - \frac{\beta}{2}V_{DS}^2$$

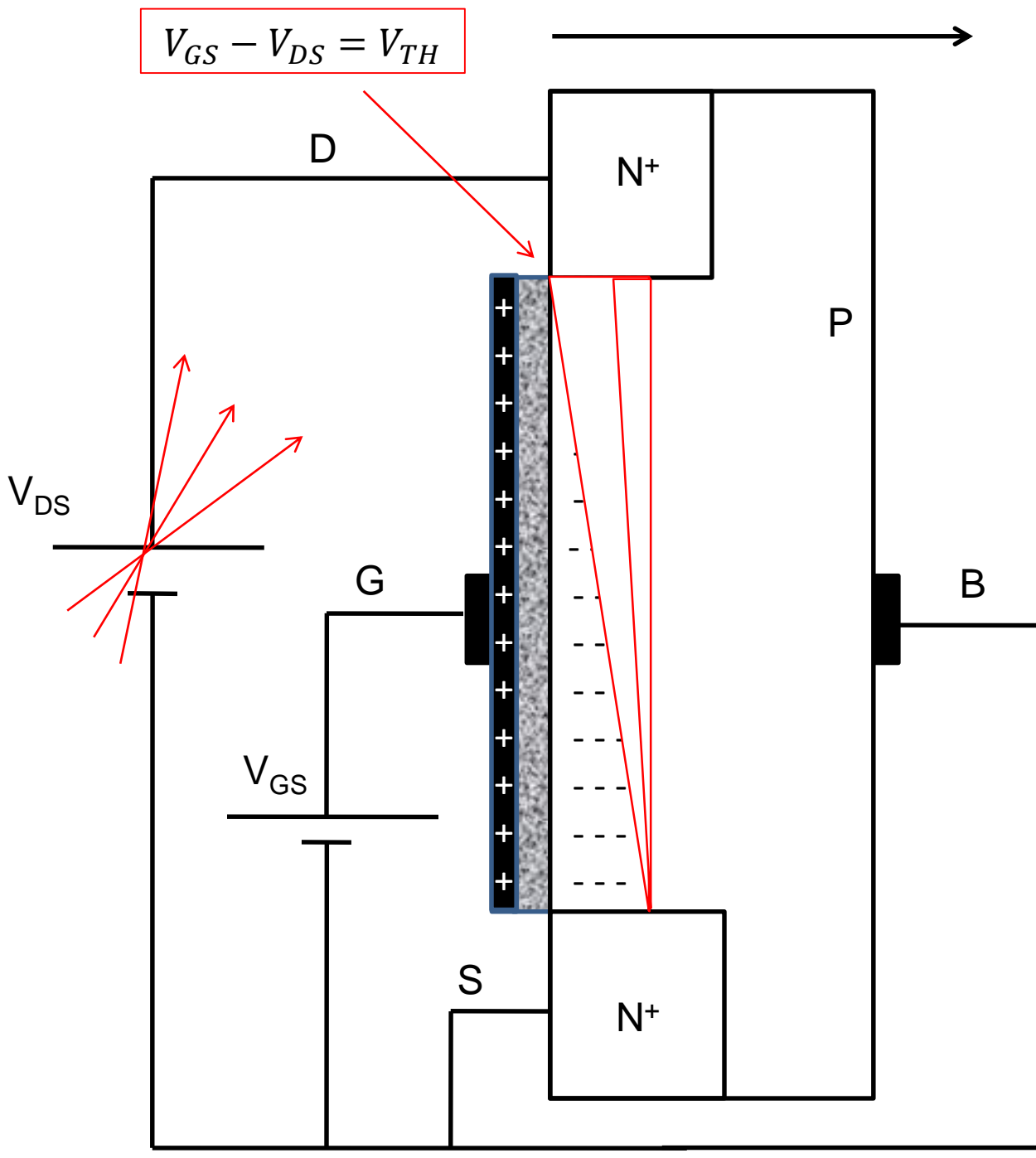
Para V_{DS} bajo

$$I_{DS} \approx \beta(V_{GS} - V_{TH})V_{DS}$$

El dispositivo entre drenador y fuente se comporta como un resistor cuyo valor es controlado por V_{GS}

$$R_{DS} = \frac{V_{DS}}{I_{DS}} = \frac{1}{\beta(V_{GS} - V_{TH})}$$





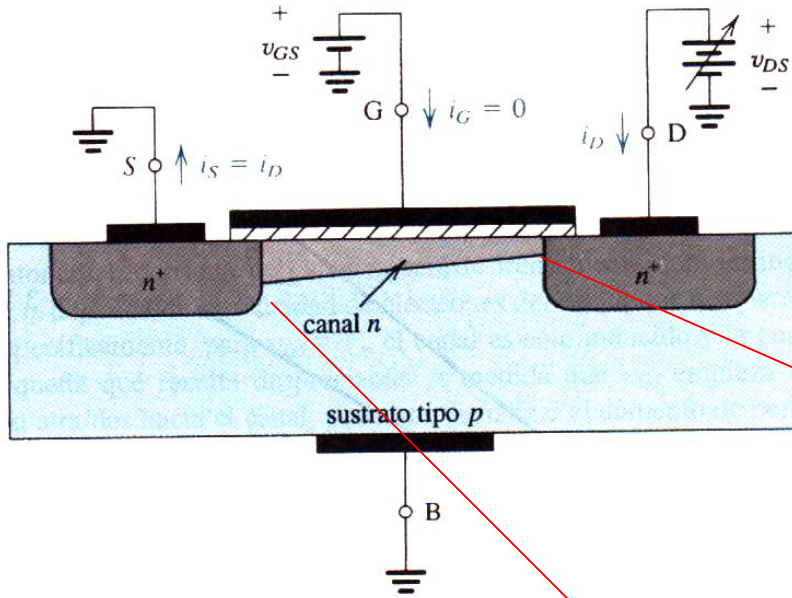
No hay portadores

SATURACION

$I_{DS} = \text{cte. y no depende de } V_{DS}$

$$I_{DS} = \frac{\beta}{2} (V_{GS} - V_{TH})^2$$

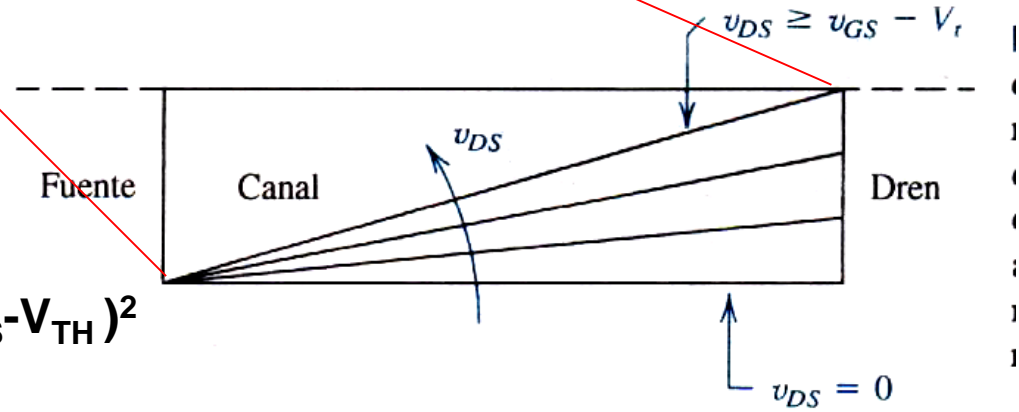
SATURACION



$$I_{DS} = \beta (V_{GS} - V_{TH}) V_{DS} - \frac{\beta}{2} V_{DS}^2$$

$$(V_{GS} - V_{DS}) < V_{TH}$$

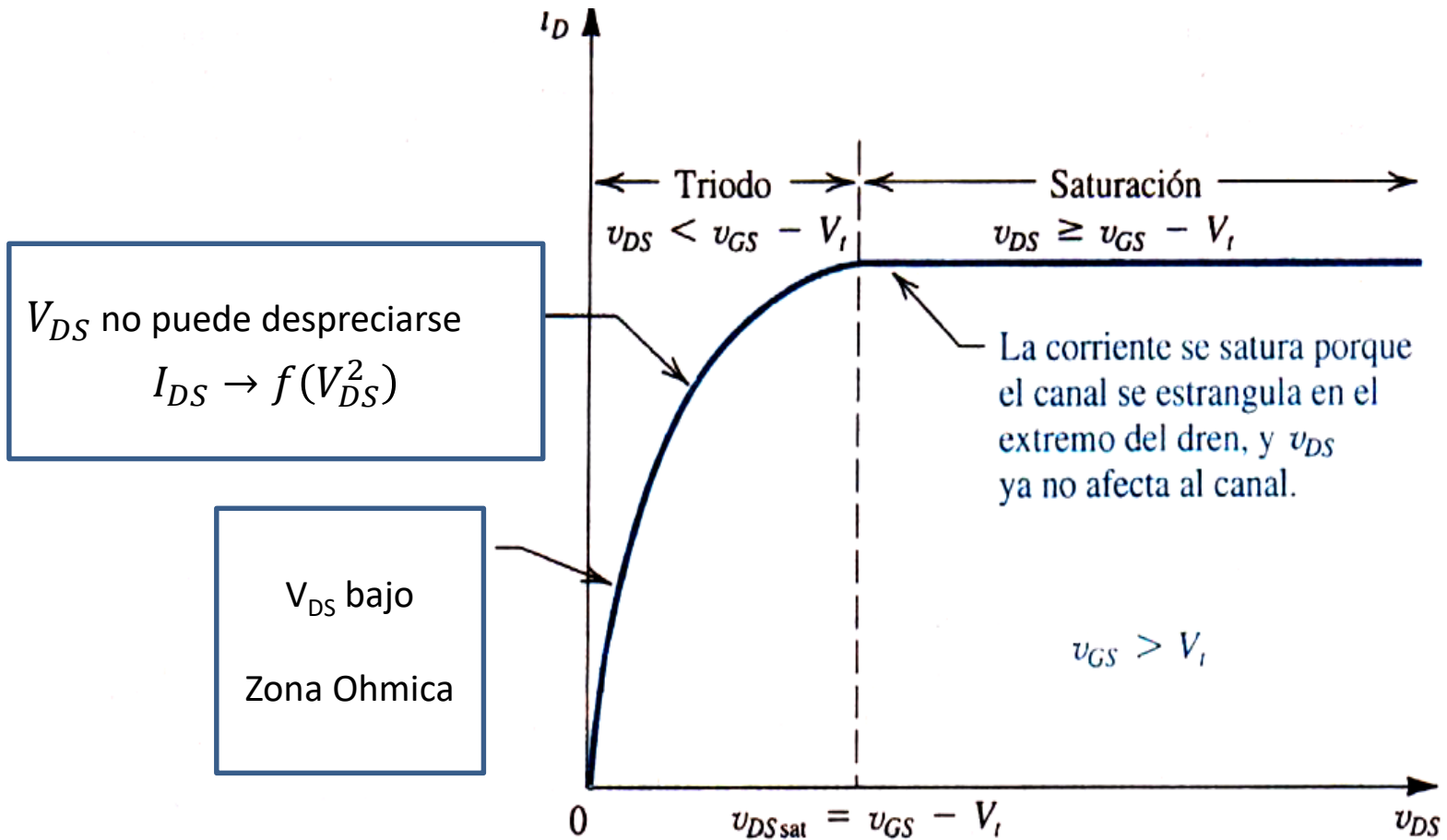
$$V_{DS} = (V_{GS} - V_{TH})$$



$$I_{DS} = \beta (V_{GS} - V_{TH}) (V_{GS} - V_{TH}) - \frac{\beta}{2} (V_{GS} - V_{TH})^2$$


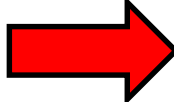

$$I_{DS} = \frac{\beta}{2} (V_{GS} - V_{TH})^2$$


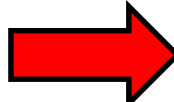

$$I_{DS} = \beta(V_{GS} - V_{TH})V_{DS} - \frac{\beta}{2}V_{DS}^2$$



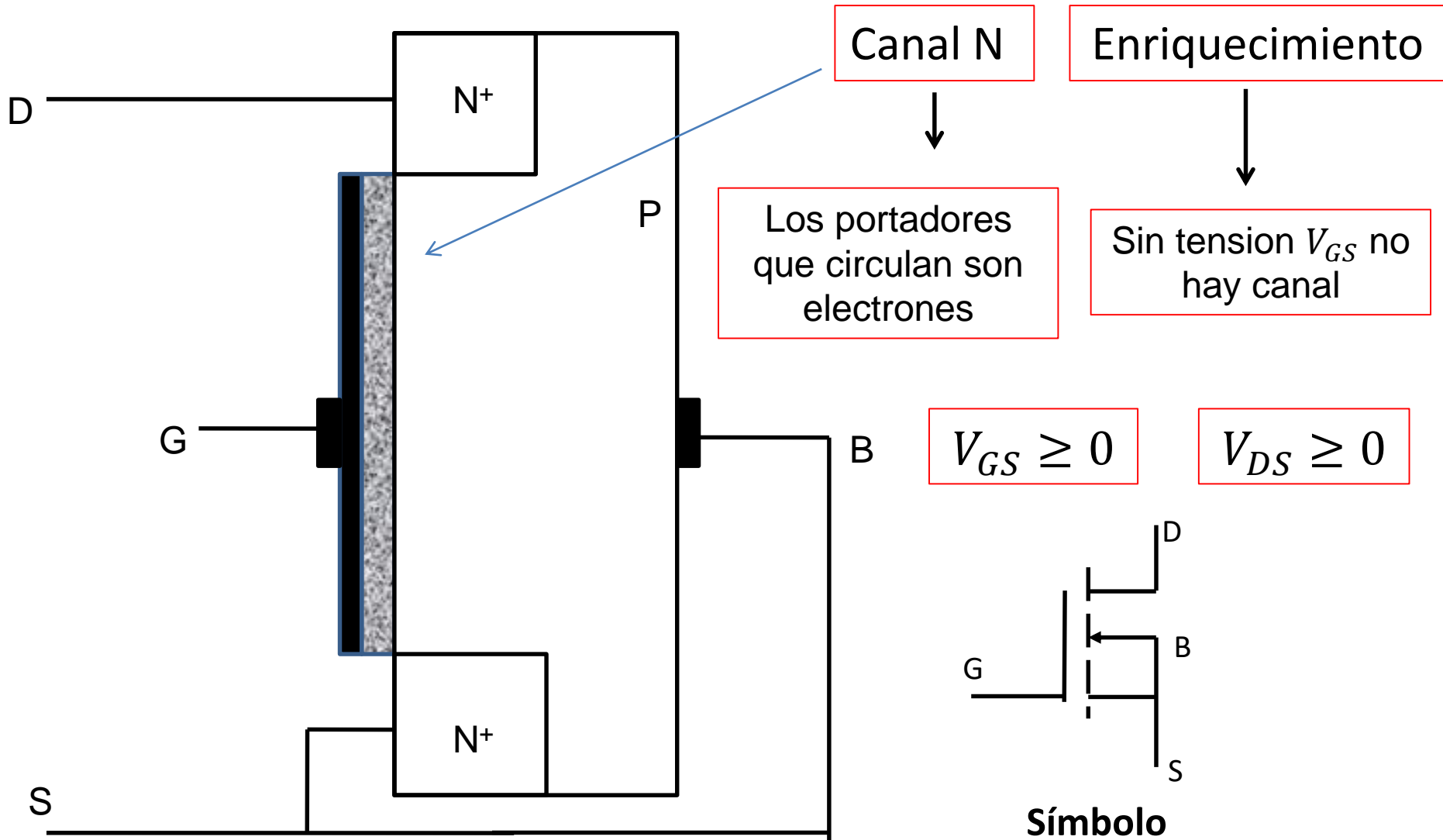
ZONAS DE OPERACION

Corte  $V_{GS} < V_{TH}$  $I_{DS} = 0$

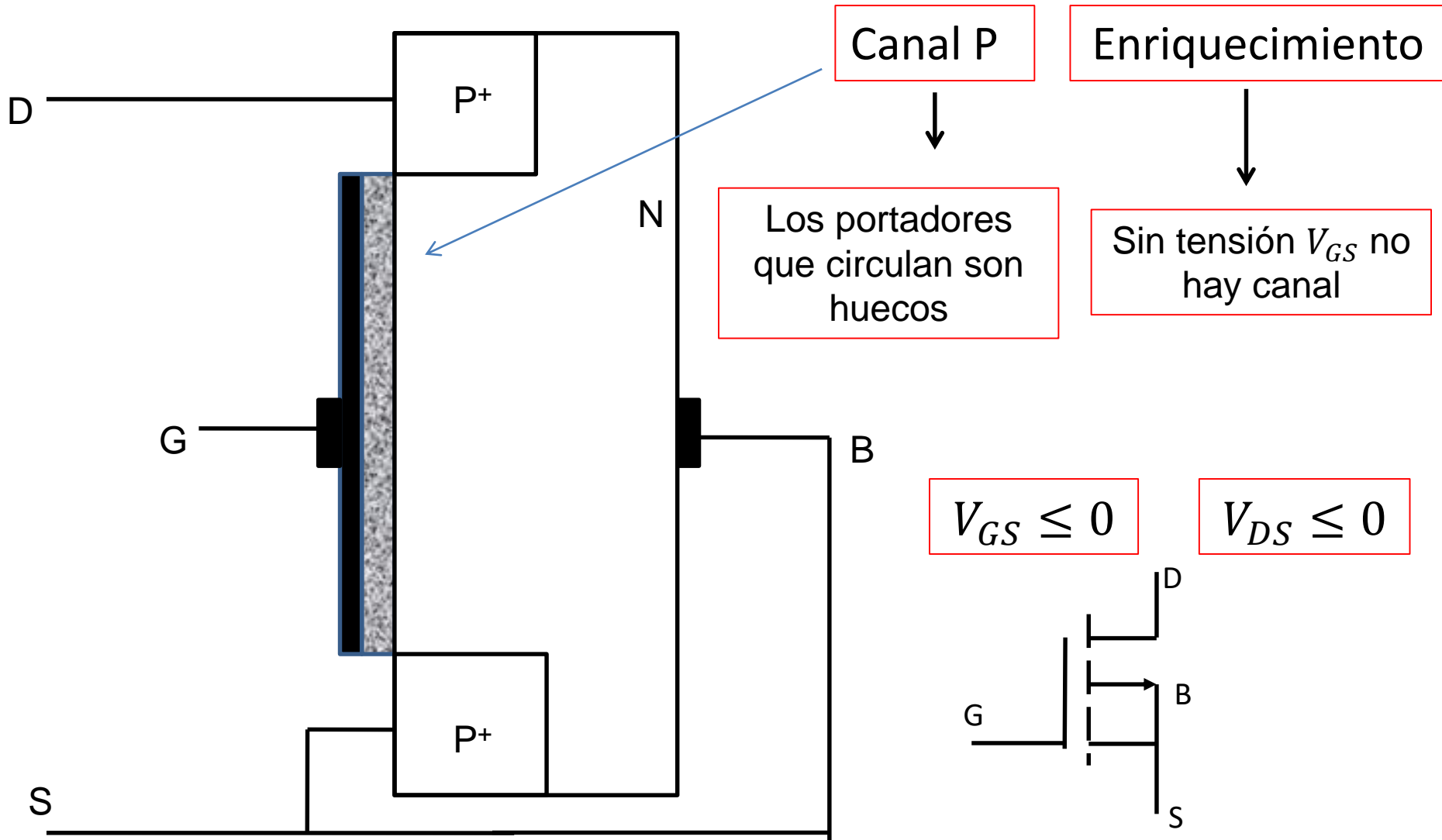
Ohmica  $V_{GS} \geq V_{TH}$  $I_{DS} = \beta(V_{GS} - V_{TH})V_{DS} - \frac{\beta}{2}V_{DS}^2$
 $V_{GS} - V_{DS} \geq V_{TH}$

Saturación  $V_{GS} \geq V_{TH}$  $I_{DS} = \frac{\beta}{2}(V_{GS} - V_{TH})^2$
 $V_{GS} - V_{DS} \leq V_{TH}$

MOS FET Canal N Enriquecimiento

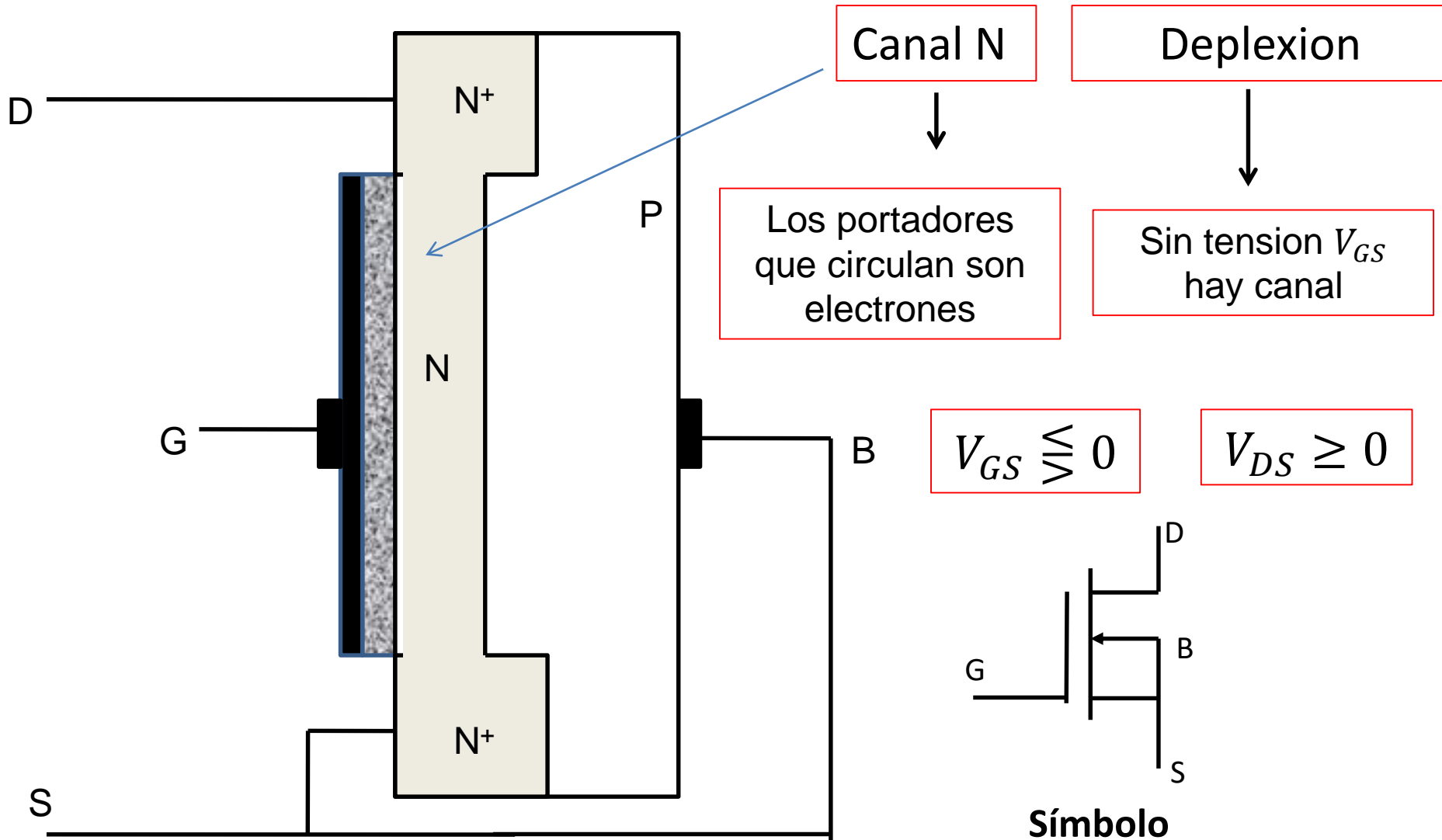


MOS FET Canal P Enriquecimiento

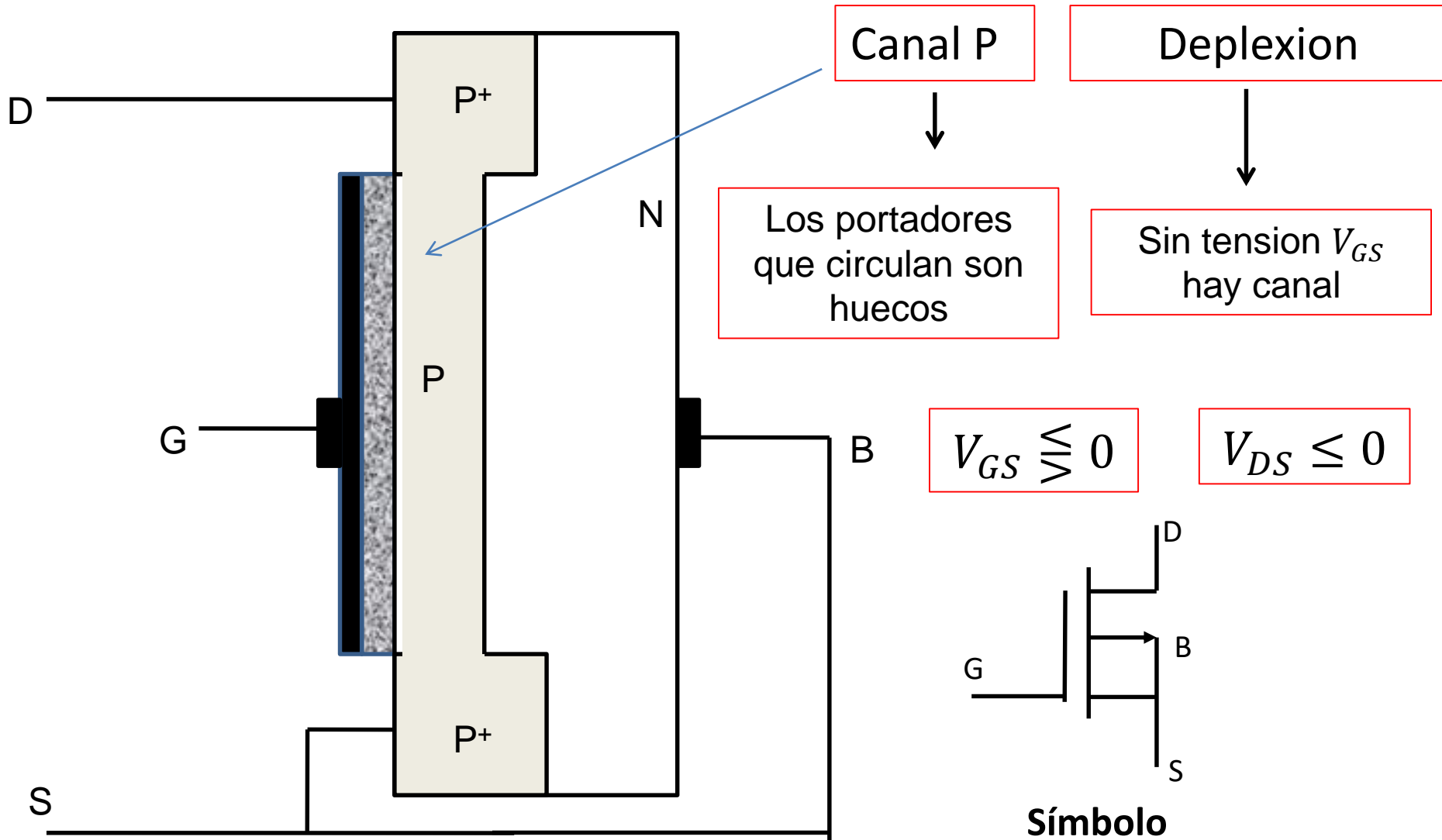


Símbolo

MOS FET Canal N Deplexion

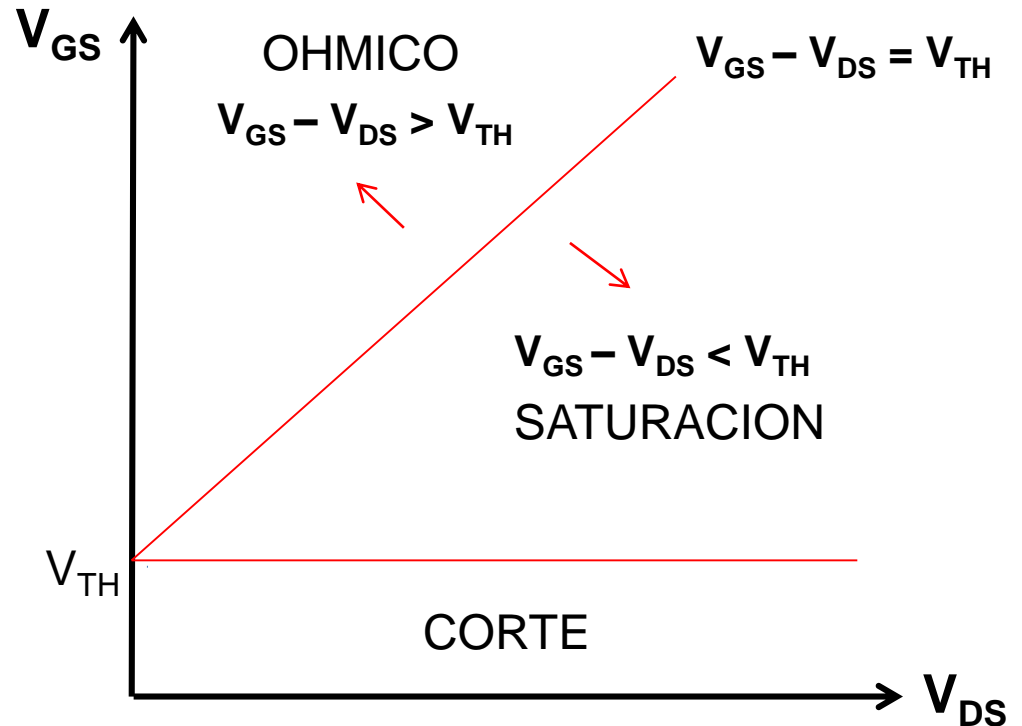
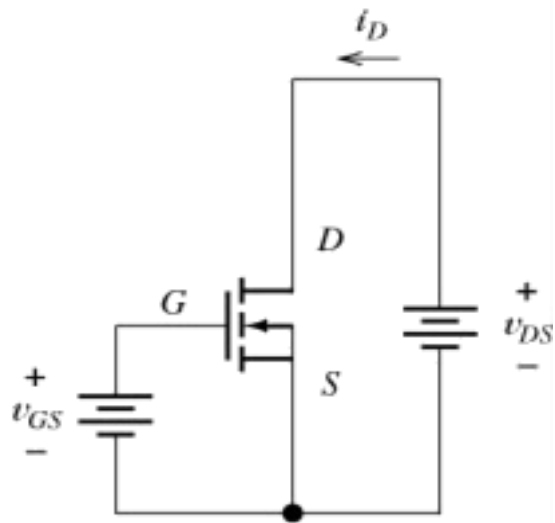
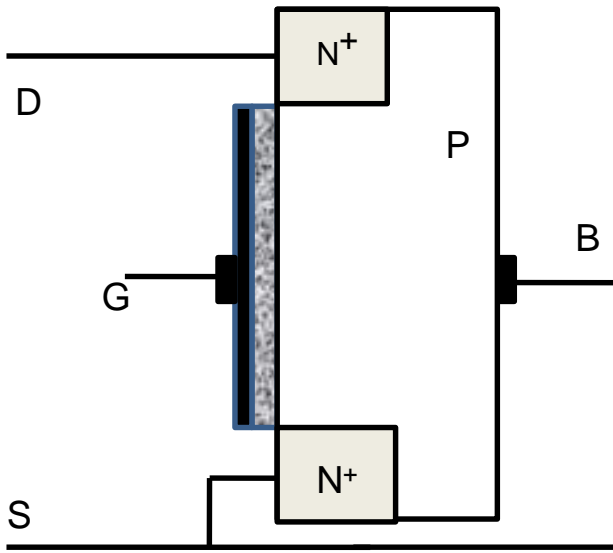


MOS FET Canal P Deplexion

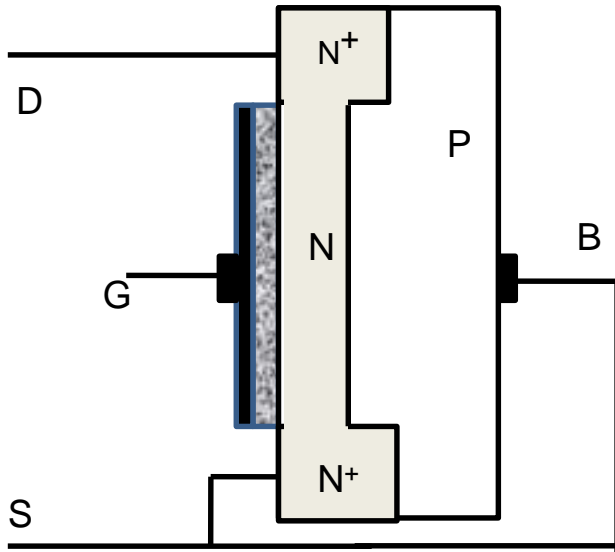


MOS FET Canal N Enriquecimiento

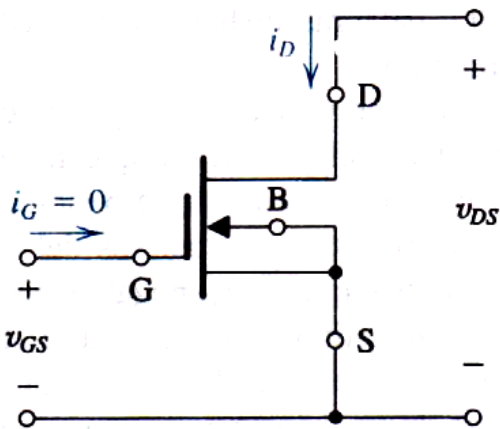
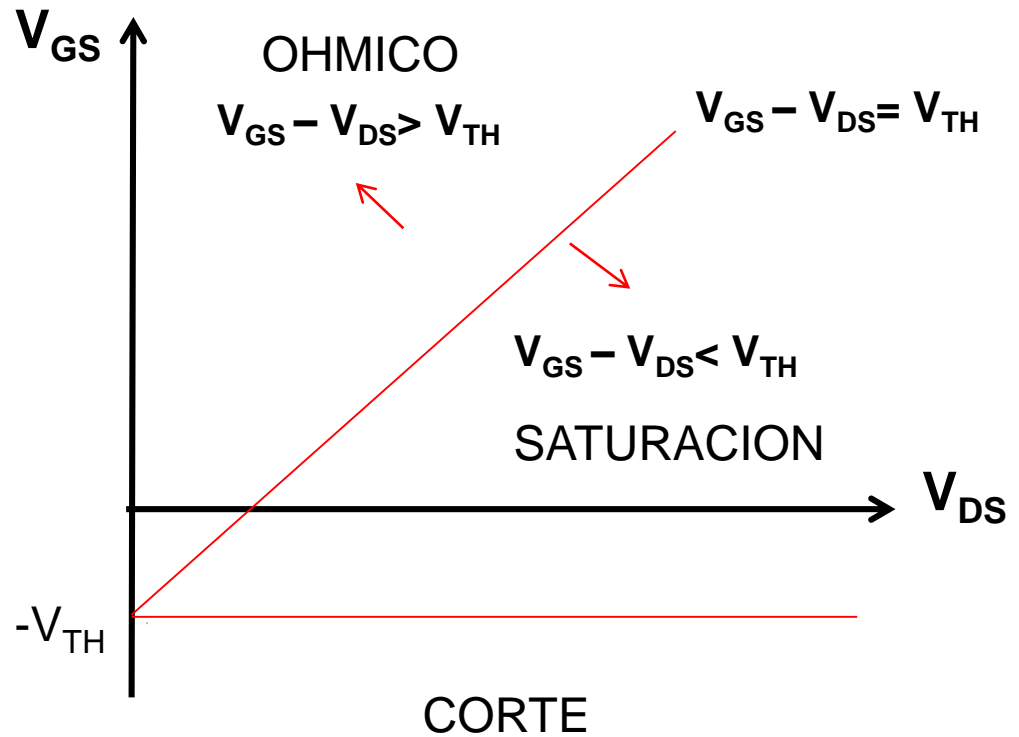
V_{GS} vs V_{DS}



MOS FET Canal N Deplexion

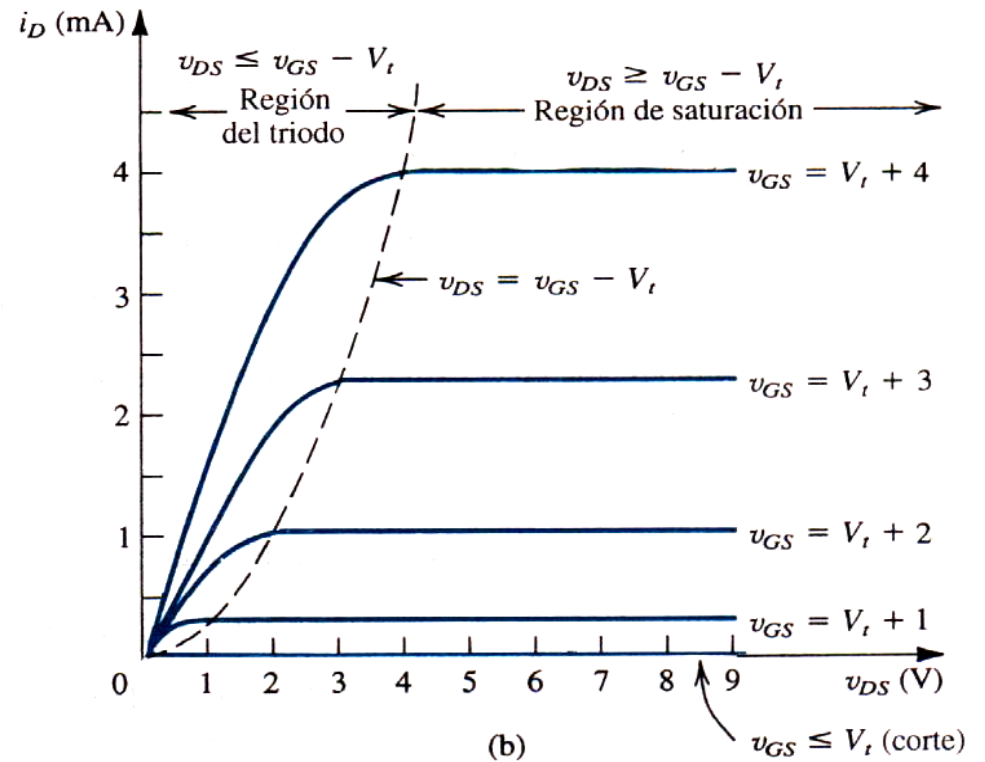
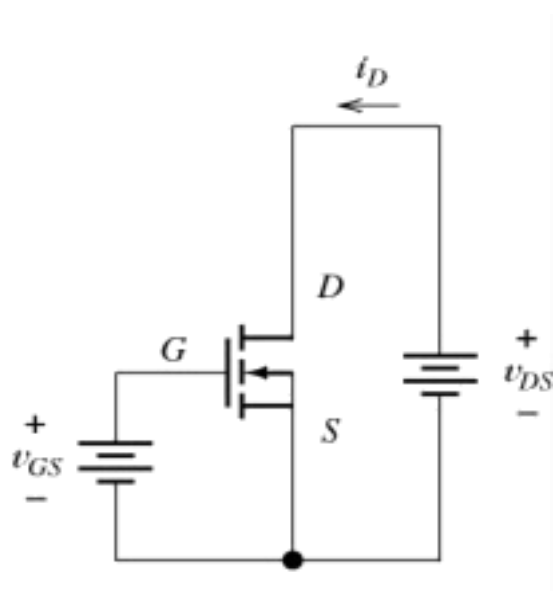


V_{GS} vs V_{DS}

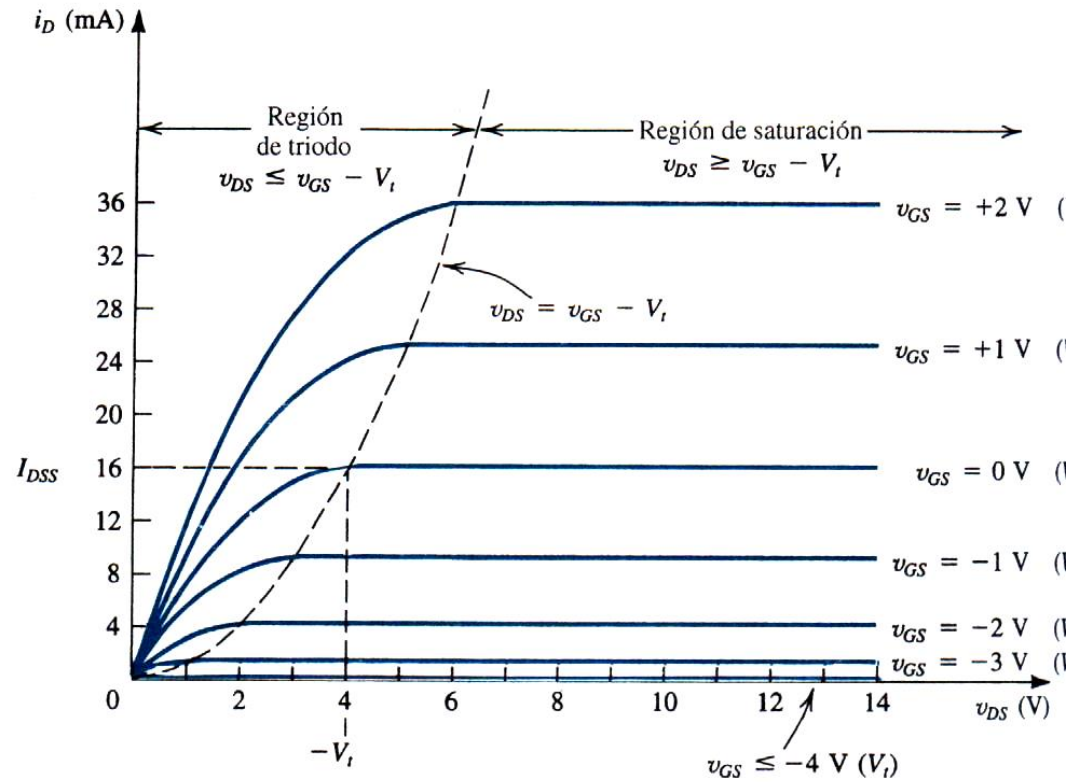
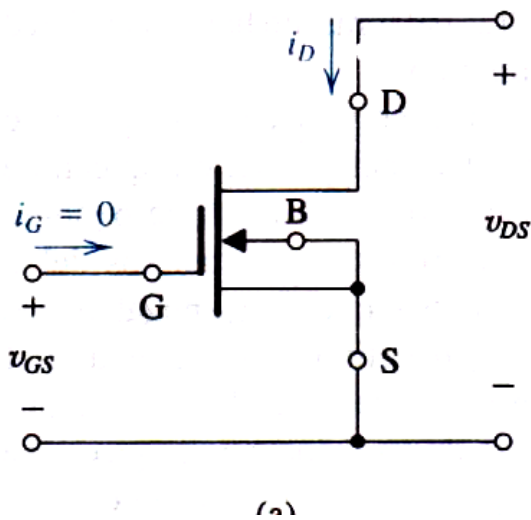


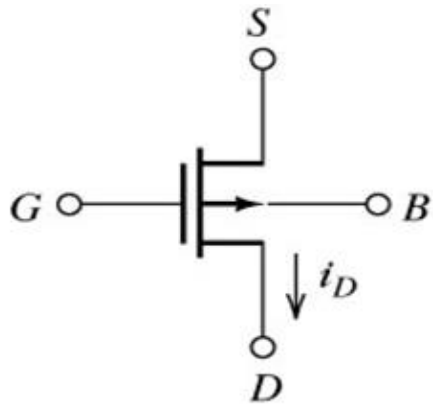
(a)

Característica V-I MOS de Enriquecimiento

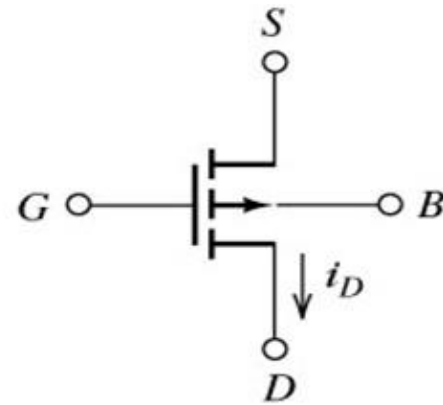


Característica V-I MOS de Deplexión

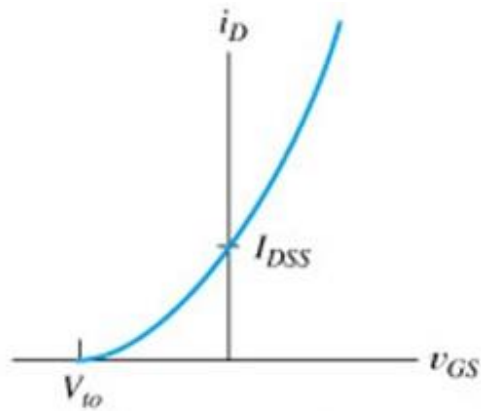




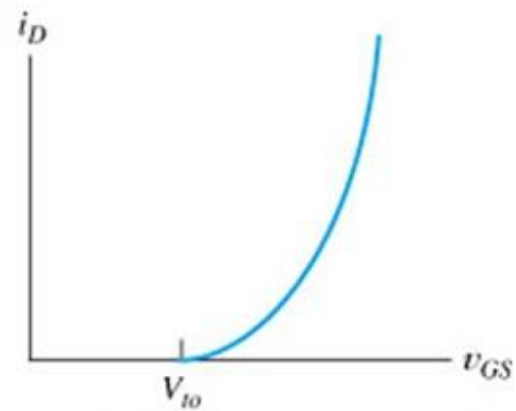
(b) Depletion MOSFET



(c) Enhancement MOSFET

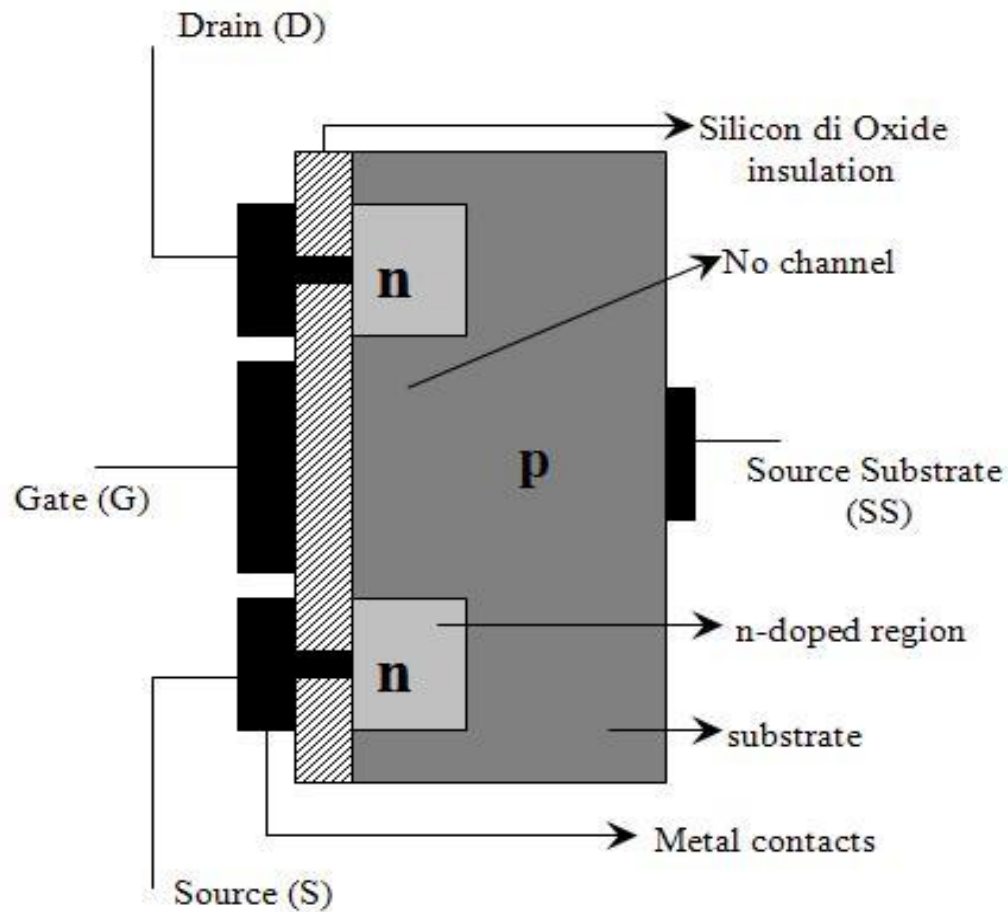


(b) Depletion MOSFET

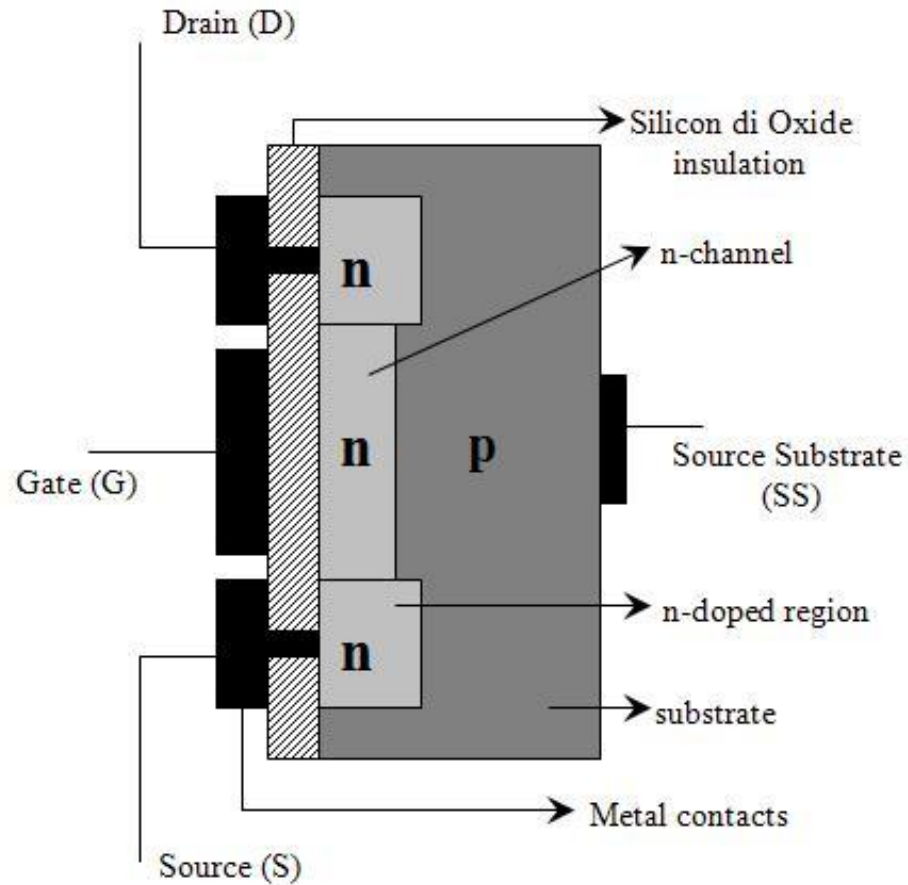


(c) Enhancement MOSFET

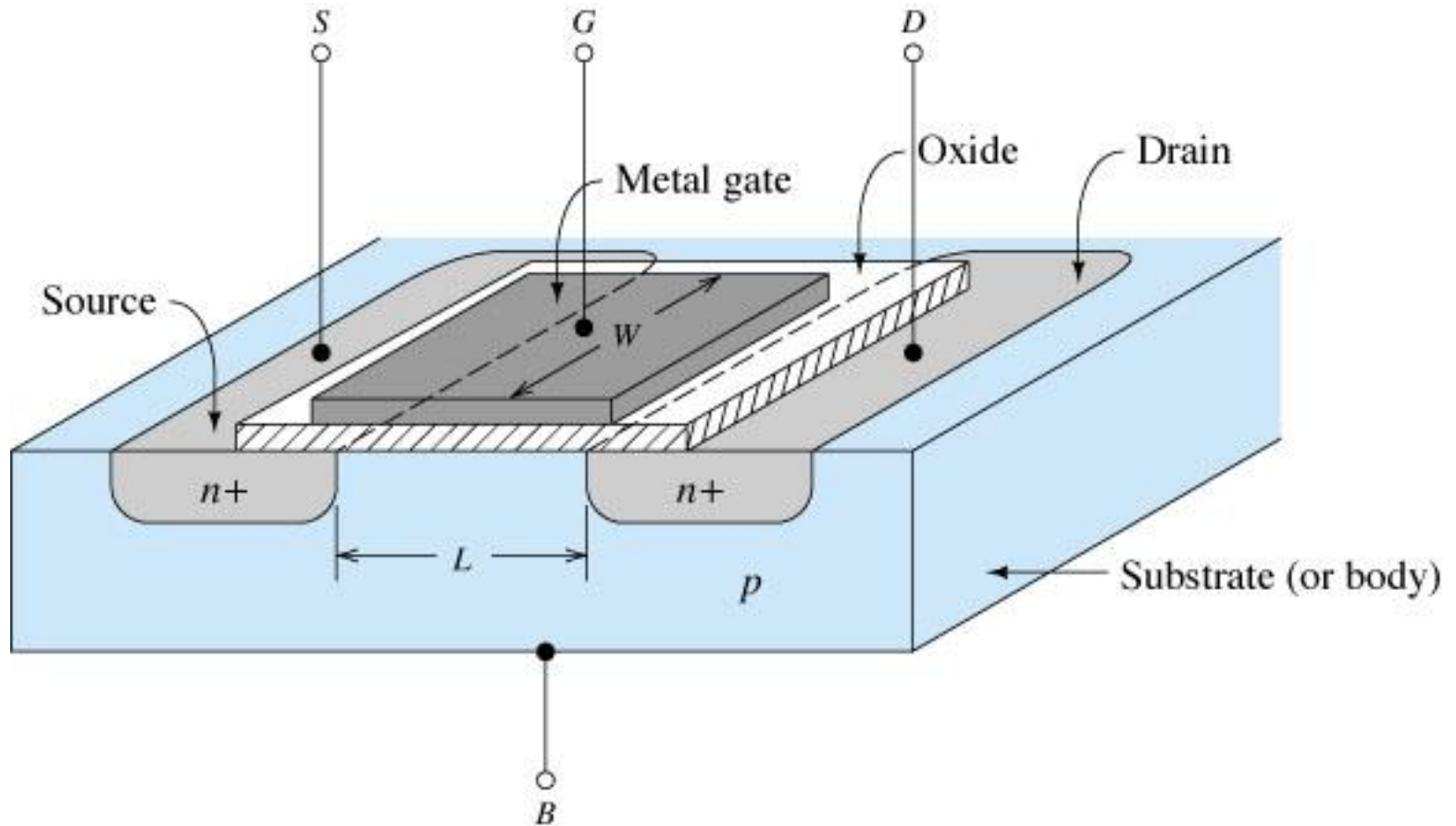
MOS de Enriquecimiento



MOS de Deplexión



Estructura Física



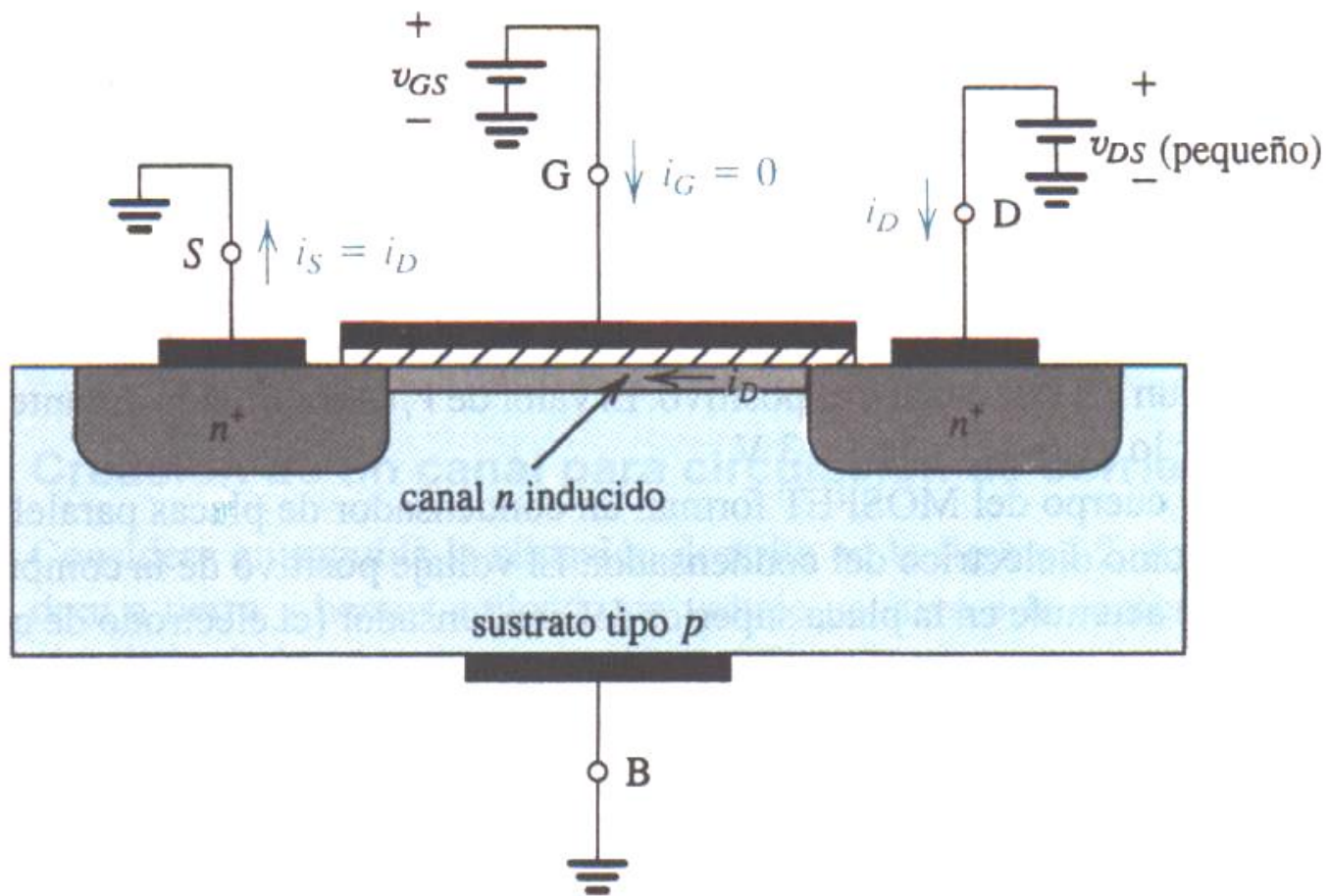
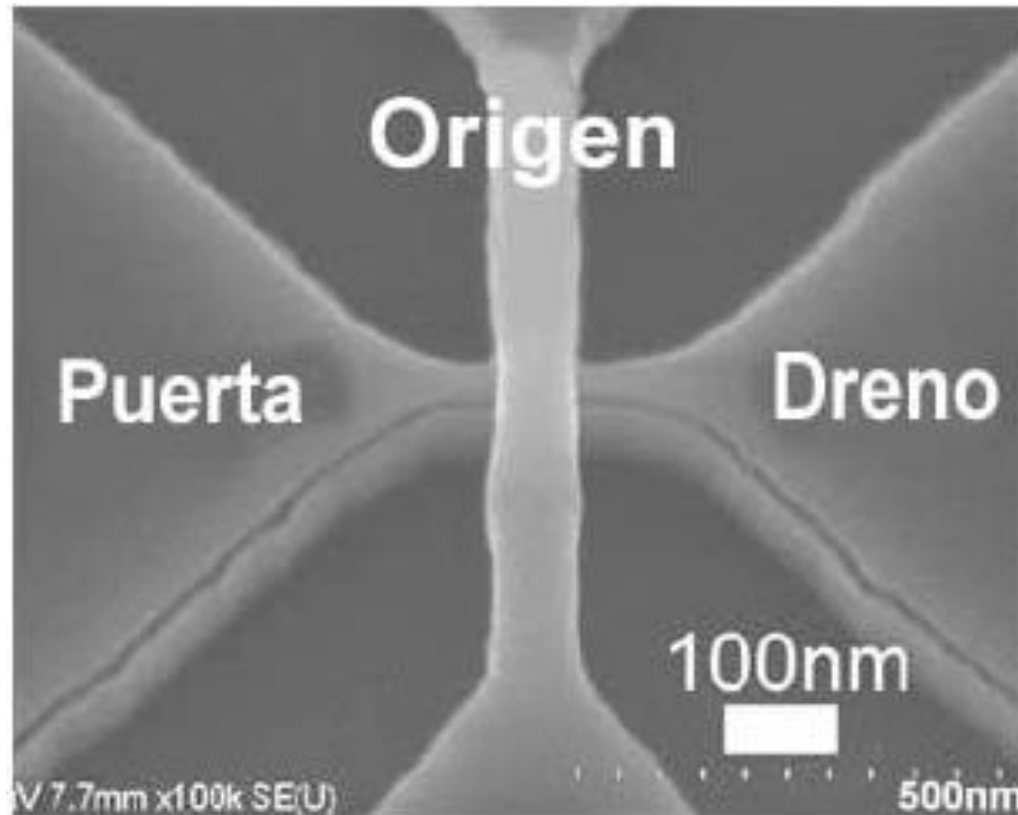
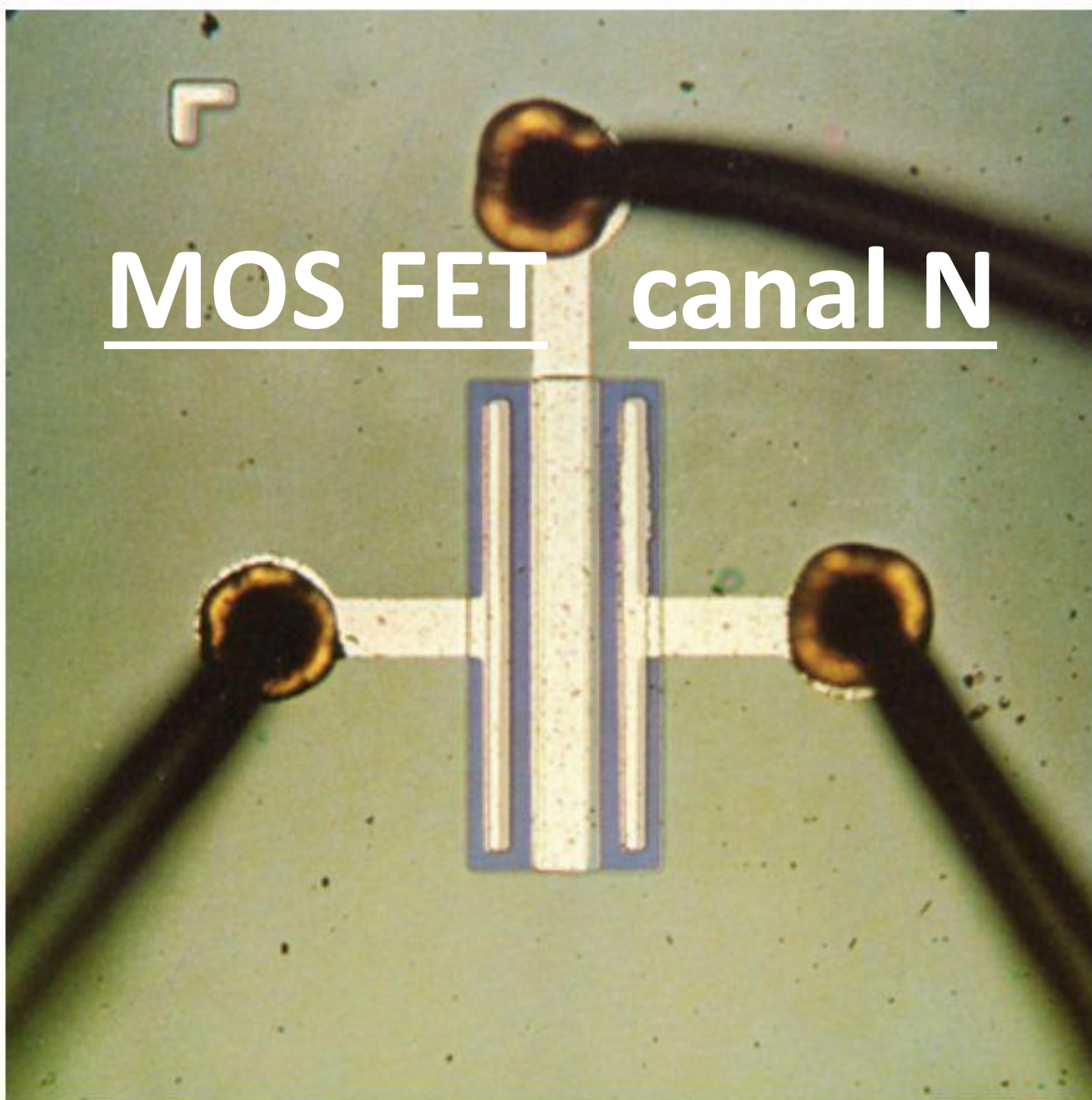


Imagen de un MOS



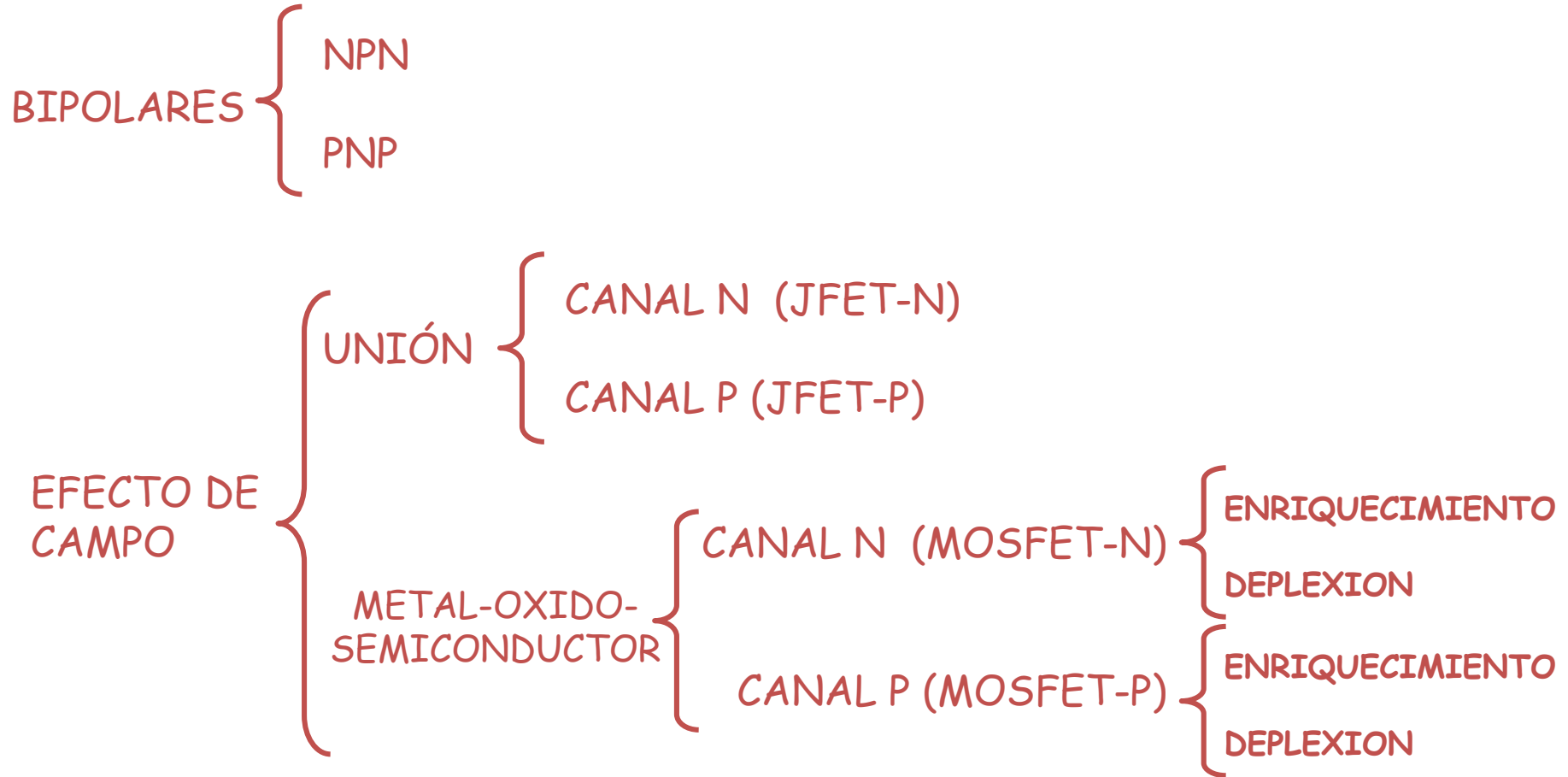
MOS FET canal N



Fairchild FI 100 p -channel MOS switching transistor.

Credit: Fairchild Camera & Instrument Corporation.

Transistores



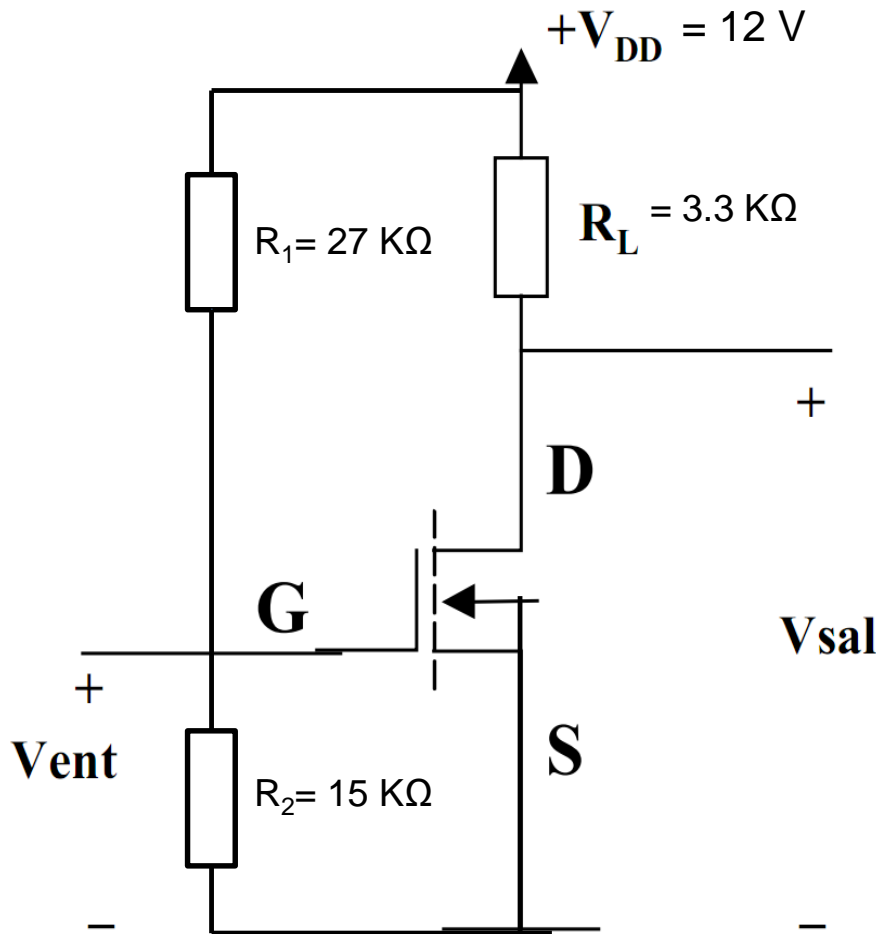
Dr Julius Lilienfield (Alemania) en 1926 patentó el concepto de "*Field Effect Transistor*".

Dr Martín Atalla y Dr Dawon Kahng desarrollaron el primer MOSFET en los laboratorios Bell en 1960

MOSFET

$$\beta = 2 \text{ mA/V}^2$$

$$V_{TH} = 2 \text{ V}$$



$$V_{GS} = \frac{V_{DD} \times R_2}{R_1 + R_2} \quad V_{GS} = 4,28 \text{ V}$$

$$V_{DS} = V_{DD} - I_{DS} \times R_L$$

Que ecuación uso para calcular I_{DS}

1 - Supongo Saturación

$$V_{GS} > V_{TH} \text{ y } V_{GS} - V_{DS} < V_{TH}$$

$$I_{DS} = \frac{\beta}{2} (V_{GS} - V_{TH})^2 \quad I_{DS} = 5,2 \text{ mA}$$

$$V_{DS} = V_{DD} - I_{DS} \times R_L \quad V_{DS} = -5,2 \text{ V}$$

$$V_{GS} - V_{DS} = 9,48 \text{ V}$$

No verifica la desigualdad $V_{GS} - V_{DS} \not< V_{TH}$

2 - Supongo Óhmico

$$V_{GS} > V_{TH} \text{ y } V_{GS} - V_{DS} > V_{TH}$$

$$I_{DS} = \beta^*(V_{GS} - V_{TH})^*V_{DS} - (\beta/2)*V_{DS}^2$$

Supongo V_{DS} bajo

$$I_{DS} \approx \beta^*(V_{GS} - V_{TH})^*V_{DS}$$

Reemplazo $V_{DS} = V_{DD} - I_{DS} R_L$

$$I_{DS} = \beta^*(V_{GS} - V_{TH})^* (V_{DD} - I_{DS} R_L)$$

Resuelvo para I_{DS}

$$I_{DS} = \frac{\beta(V_{GS} - V_{TH})V_{DD}}{1 + \beta(V_{GS} - V_{TH})R_L}$$

$$V_{GS} = 4,28 \text{ V}$$

$$I_{DS} = 3,4 \text{ mA}$$

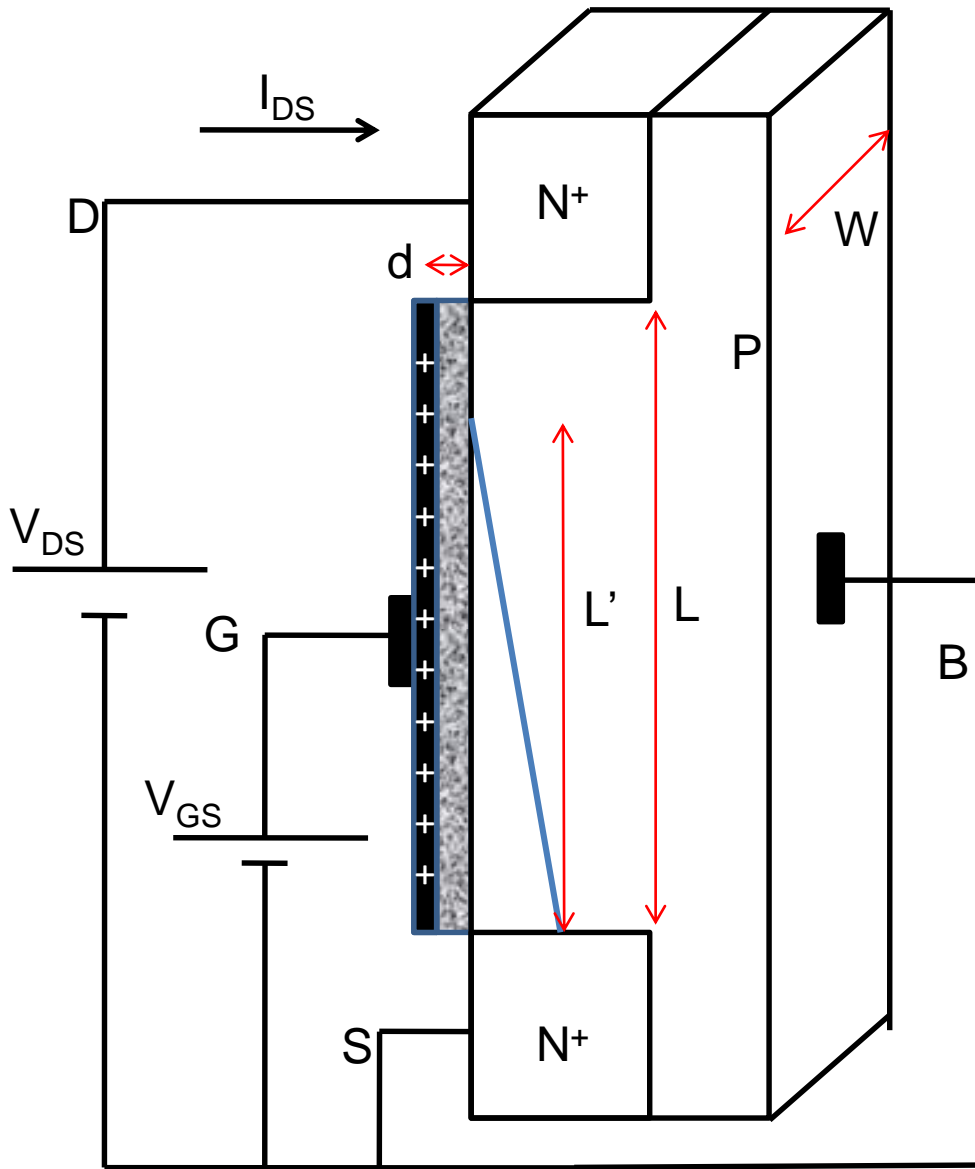
$$V_{DS} = 0,78 \text{ V}$$

Verifico la desigualdad

$$V_{GS} > V_{TH} \text{ y } V_{GS} - V_{DS} > V_{TH}$$

Como paso a Saturación

Aumentando $V_{DS} \rightarrow$ Disminuyo R_L



$$I_{DS} = \frac{\beta}{2} (V_{GS} - V_{TH})^2$$

$$\beta = \frac{\mu \epsilon W}{d} \frac{1}{L}$$

$$\beta' = \frac{\mu \epsilon W}{d} \frac{1}{L'}$$

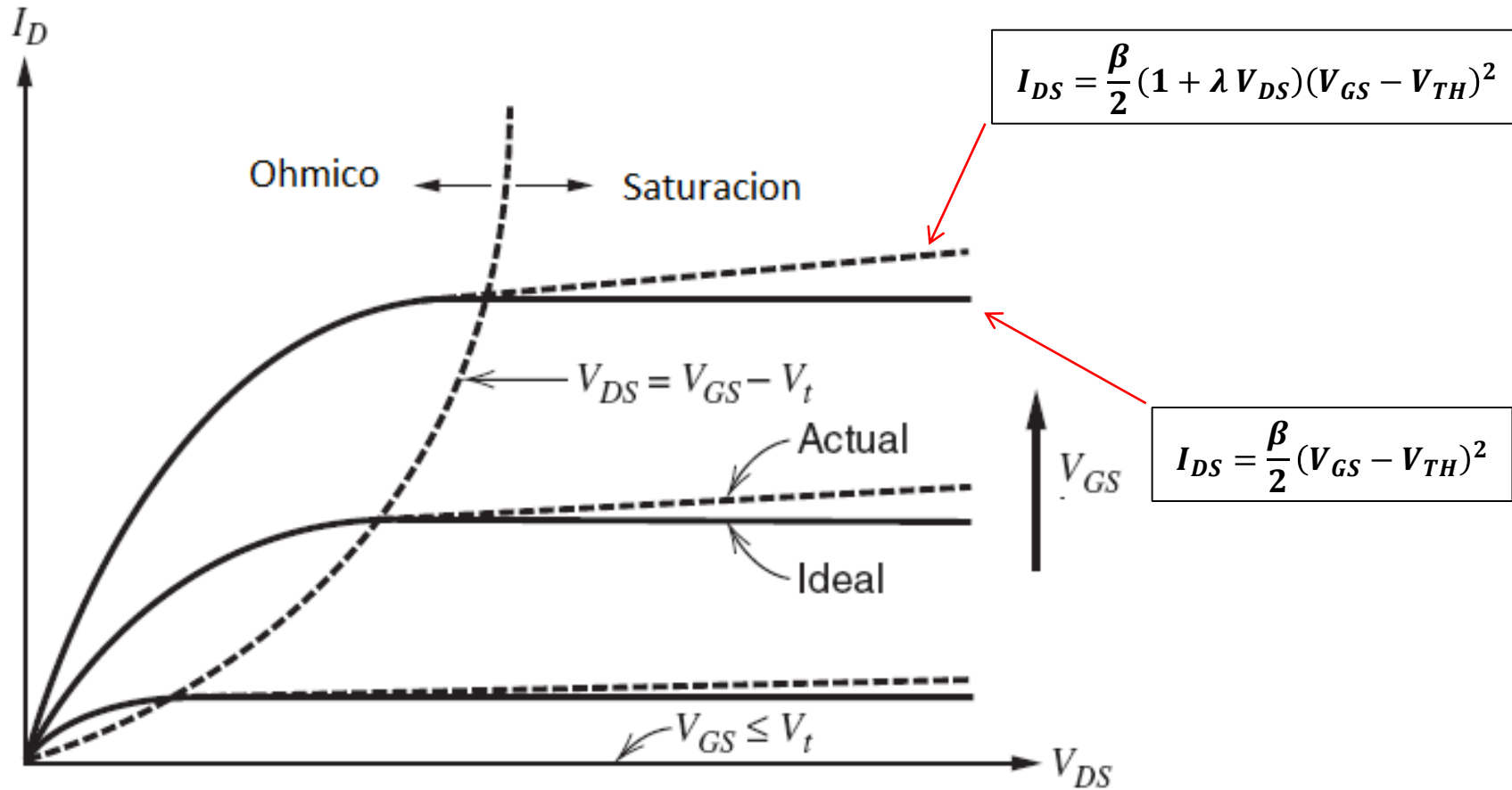
$$\beta \rightarrow f(V_{DS})$$



$$I_{DS} \rightarrow f(V_{DS})$$

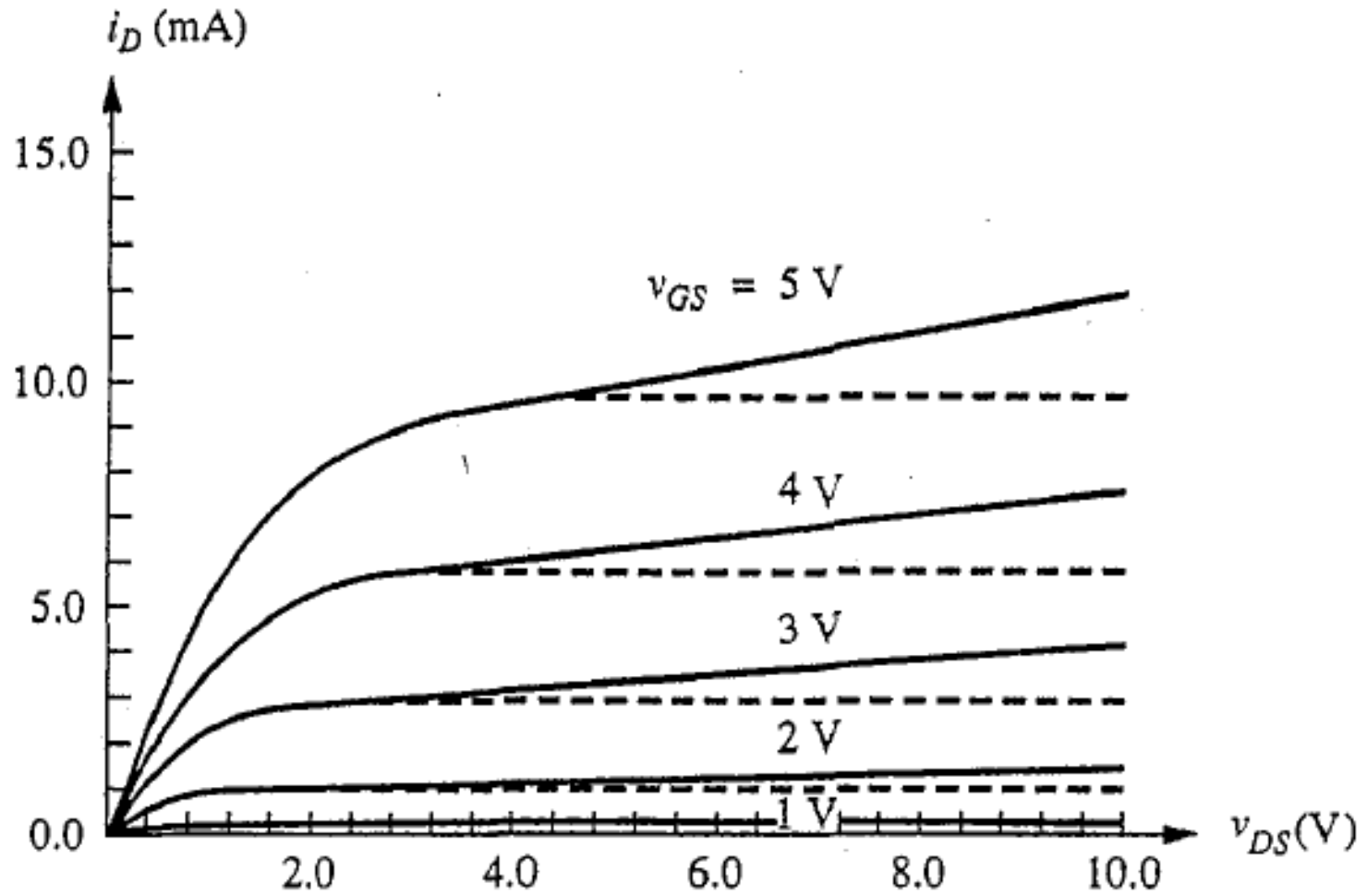
$$I_{DS} = \frac{\beta}{2} (1 + \lambda V_{DS}) (V_{GS} - V_{TH})^2$$

Modulación del largo del canal

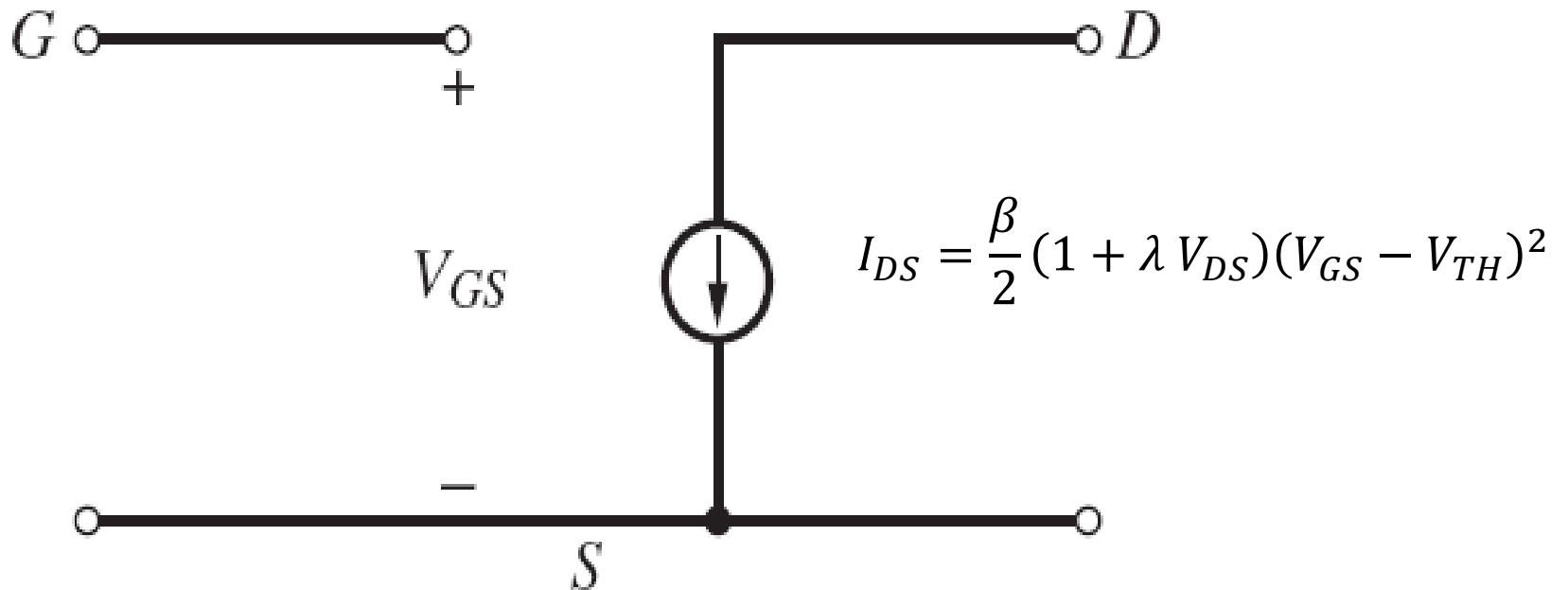


Característica I_{DS} vs V_{DS} del MOSFET

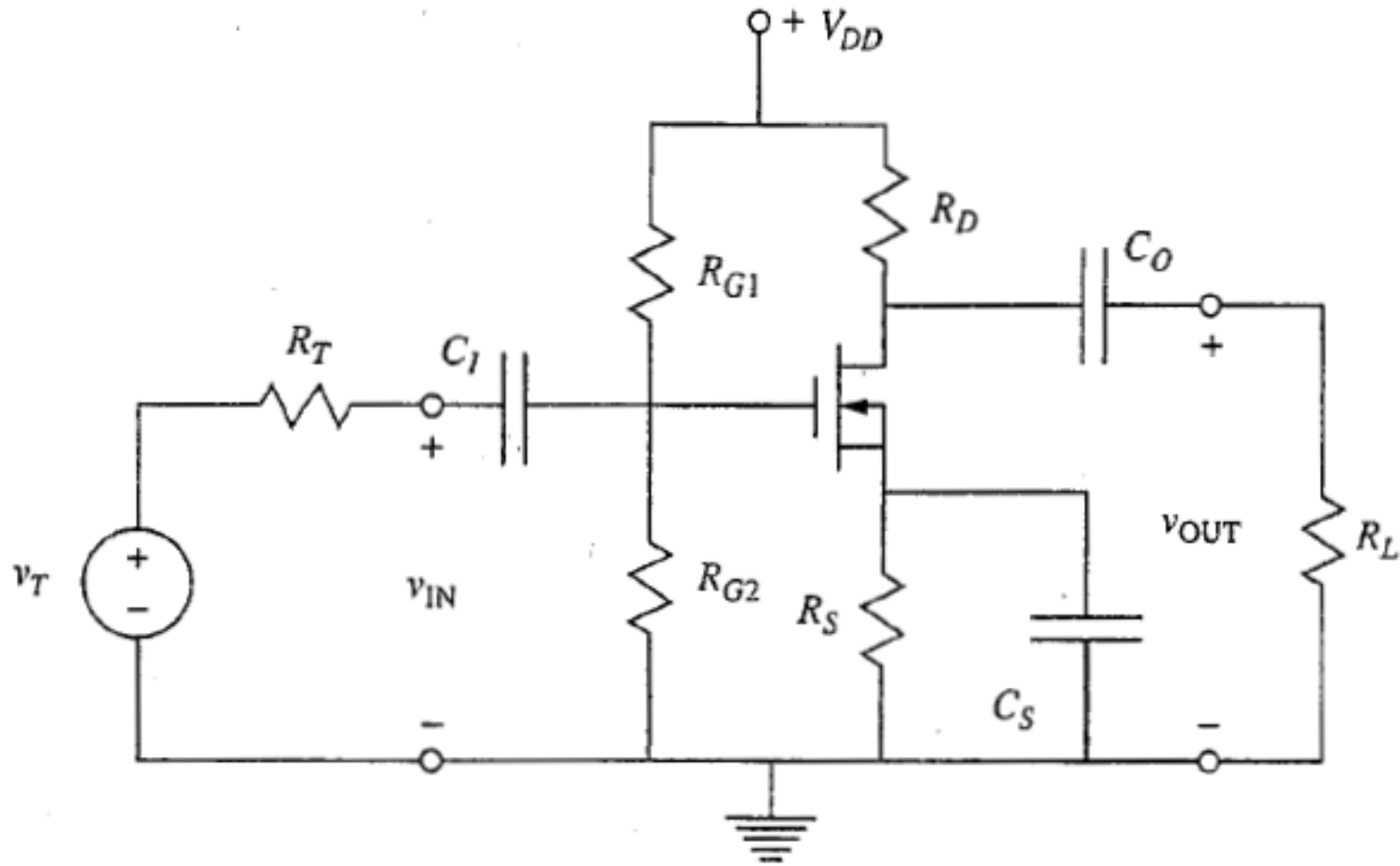
Modulación del largo del canal



Modelo de Continua del MOSFET en zona de saturación



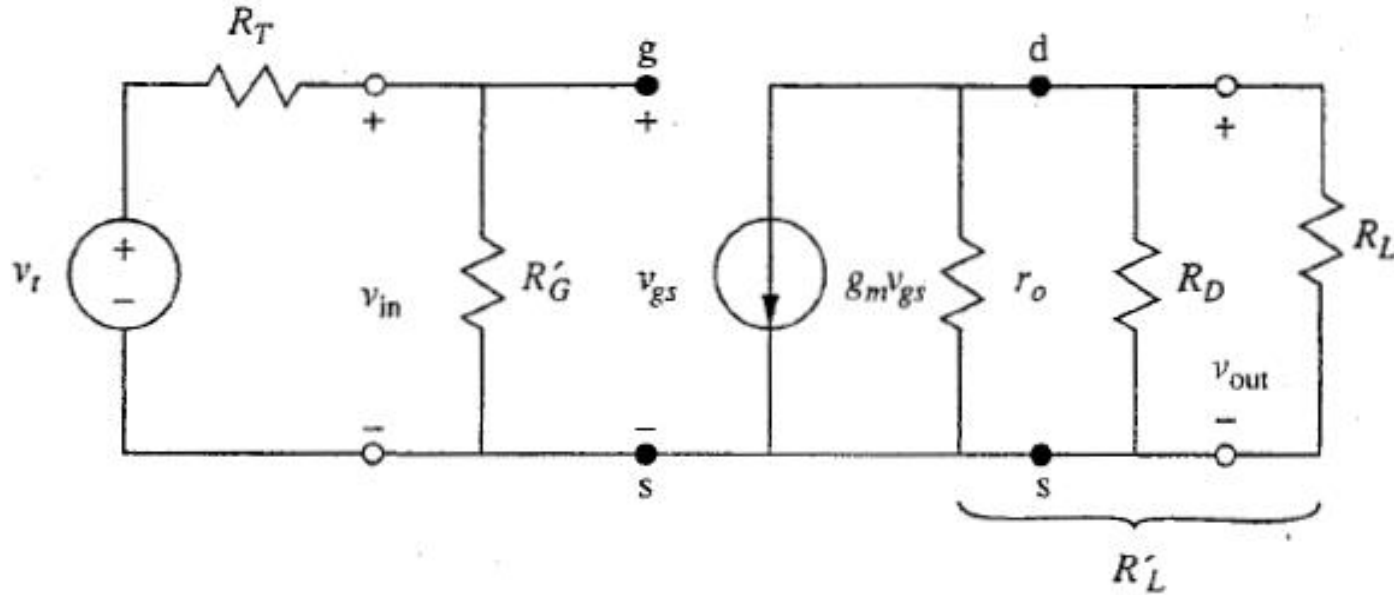
Amplificador con MOSFET



Amplificador de Fuente Común

Dispositivos Electrónicos

Modelo de Pequeña Señal del Amplificador de Fuente Común



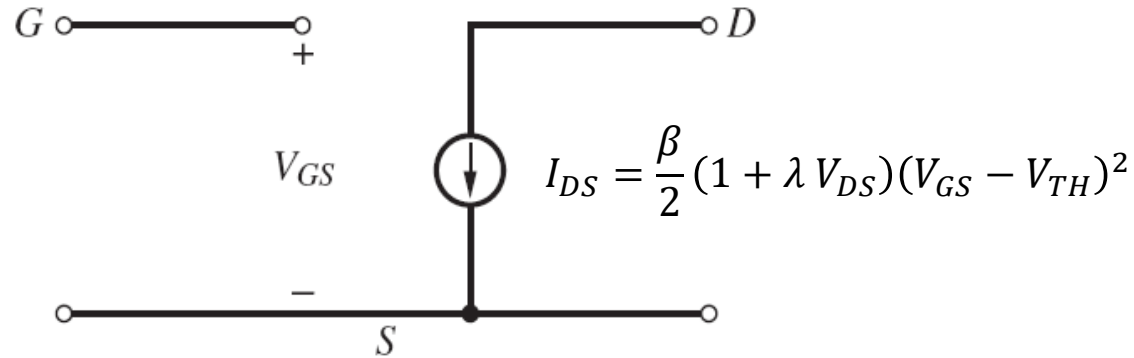
$$A_V = \frac{v_{out}}{v_{in}}$$

$v_{out} = -g_m v_{gs} R'_L$

$v_{in} = v_{gs}$

$$A_v = -g_m R'_L$$

Si el MOSFET esta polarizado en SATURACION



$$g_m = \left. \frac{dI_{DS}}{dV_{GS}} \right|_{\bar{Q}}$$

$$r_0 = \left. \frac{dV_{DS}}{dI_{DS}} \right|_{\bar{Q}}$$

$$g_m = \beta (1 + \lambda V_{DS}) (V_{GSP} - V_{TH}) \Big|_{\bar{Q}}$$

$$r_0 = \frac{1}{\lambda I_{DSP}} \Big|_{\bar{Q}}$$

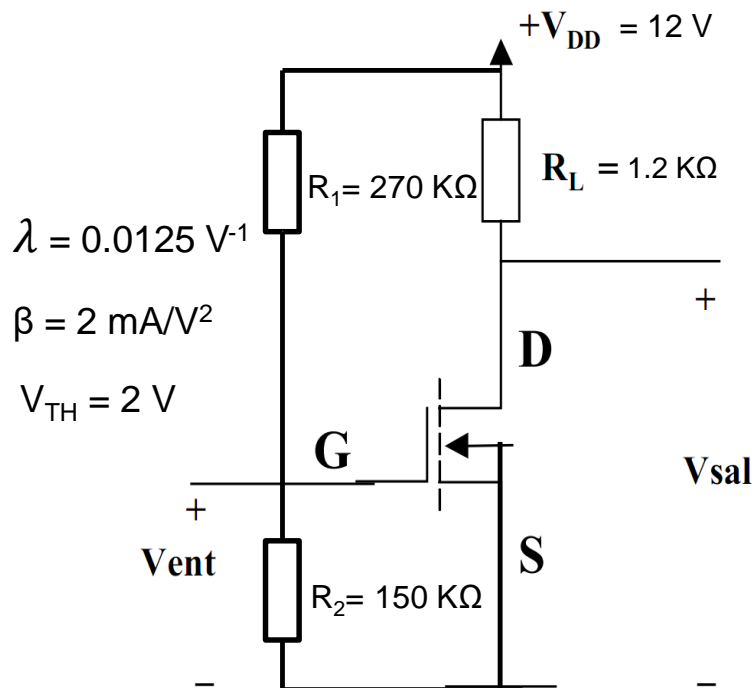
En el punto de polarización (Q)

$$V_{GS} = V_{GSP} - I_{DS} = I_{DSP} - V_{DS} = V_{DSP}$$

Ganancia de tensión $\longrightarrow A_V = -\beta(1 + \lambda V_{DS})(V_{GSP} - V_{TH})R'_L$

Resistencia de entrada $\longrightarrow R_i = R'_G$

Resistencia de salida $\longrightarrow R_o = R'_L$



$$V_{GSP} = V_{DD} \frac{R_2}{R_1 + R_2} = 4,28 \text{ V}$$

$$I_{DSP} = \frac{\beta}{2} (V_{GSP} - V_{TH})^2 = 5,2 \text{ mA}$$

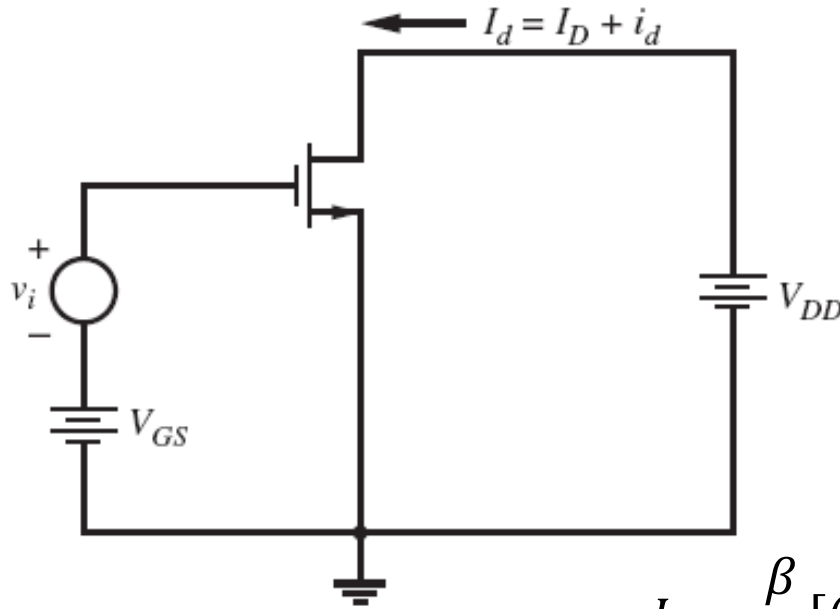
$$V_{DSP} = V_{DD} - I_{DSP} R_L = 5,76 \text{ V}$$

$$V_{GSP} - V_{DSP} = -1,48 < V_{TH} \longrightarrow \text{SATURACION}$$

$$A_V = -\beta(1 + \lambda V_{DS})(V_{GSP} - V_{TH})R'_L = -5,48$$

$$R_i = R'_G = 96 \text{ K}\Omega$$

Validez del Modelo de Pequeña Señal del MOSFET



Considerando $\lambda V_{DS} \ll 1$



$$I_d = \frac{\beta}{2} (V_{GS} + v_i - V_{TH})^2$$

$$I_d = \frac{\beta}{2} [(V_{GS} - V_{TH})^2 + 2(V_{GS} - V_{TH})v_i + v_i^2]$$

$$I_d = I_D + \frac{\beta}{2} [2(V_{GS} - V_{TH})v_i + v_i^2]$$

$$i_d = I_d - I_D \qquad i_d = \frac{\beta}{2} [2(V_{GS} - V_{TH})v_i + v_i^2]$$

$$i_d = \beta(V_{GS} - V_{TH}) v_i \left[1 + \frac{v_i}{2(V_{GS} - V_{TH})} \right]$$

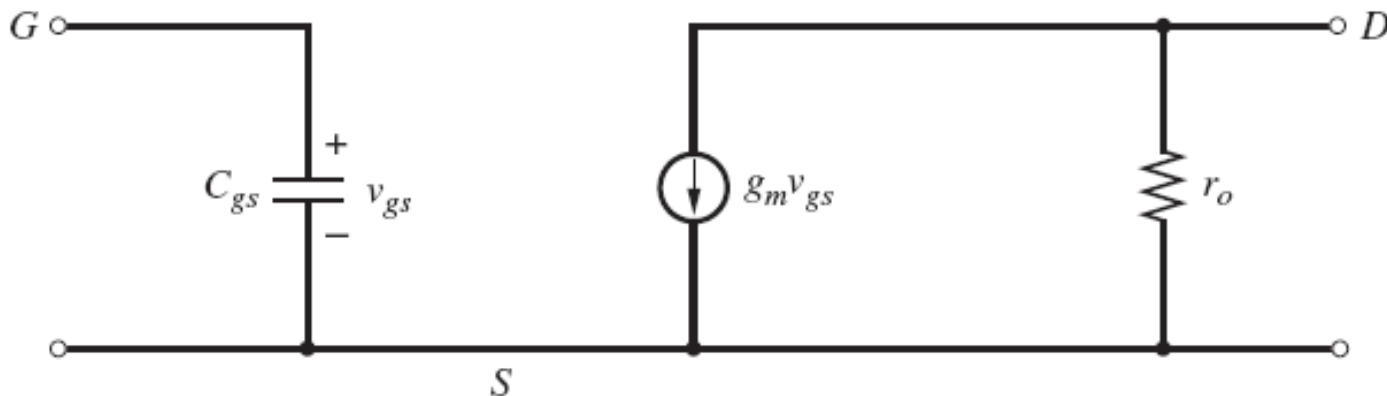
Si $v_i \ll 2(V_{GS} - V_{TH})$



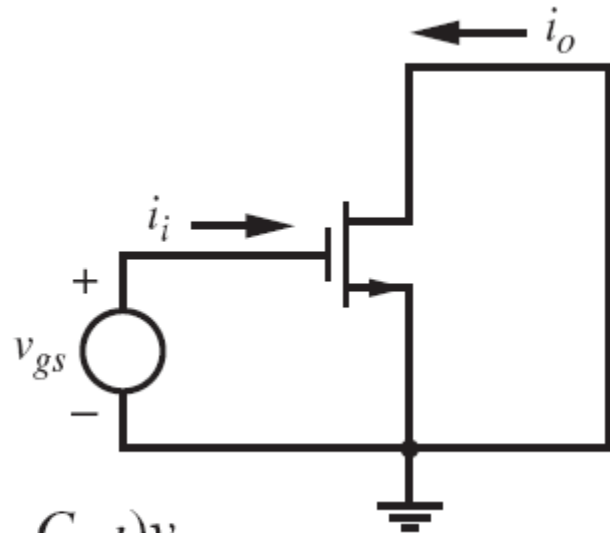
Condición para la validez del modelo de pequeña señal

$$i_d = \beta(V_{GS} - V_{TH}) v_i$$

$$g_m = \beta(V_{GS} - V_{TH})$$

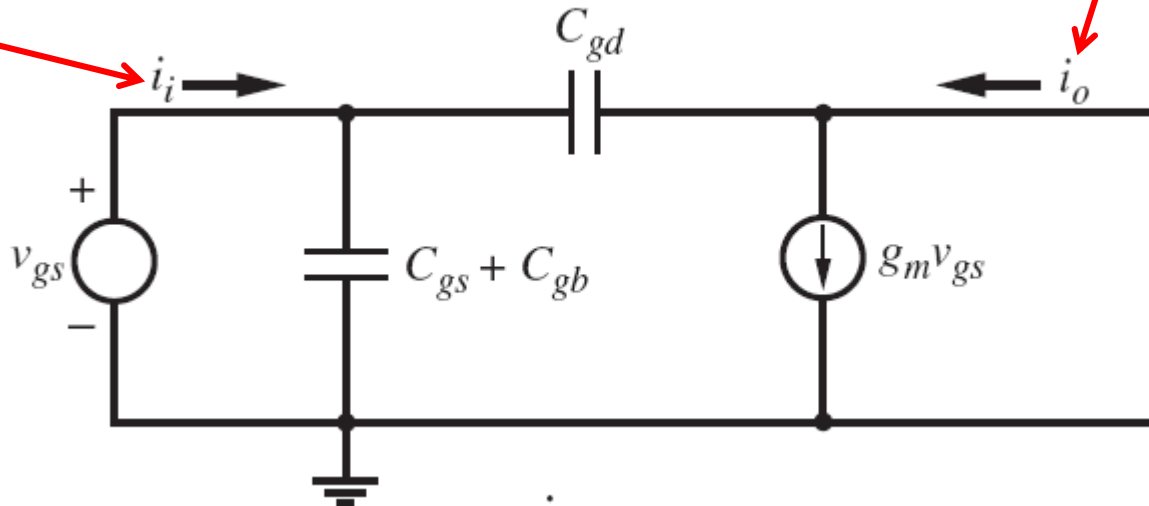


Respuesta en frecuencia del MOSFET



$$i_i = s(C_{gs} + C_{gb} + C_{gd})v_{gs}$$

$$i_o \simeq g_m v_{gs}$$



$$\frac{i_o}{i_i} \simeq \frac{g_m}{s(C_{gs} + C_{gb} + C_{gd})}$$

$$\frac{i_o}{i_i} \simeq \frac{g_m}{j\omega(C_{gs} + C_{gb} + C_{gd})}$$

$$\omega = \omega_T = \frac{g_m}{C_{gs} + C_{gb} + C_{gd}}$$

$$f_T = \frac{1}{2\pi} \omega_T = \frac{1}{2\pi} \frac{g_m}{C_{gs} + C_{gb} + C_{gd}}$$

$$C_{gs} \gg (C_{gb} + C_{gd}) \quad \longrightarrow \quad f_T = \frac{1}{2\pi} \frac{g_m}{C_{gs}}$$

$$f_T = \frac{1}{2\pi} \frac{\beta(V_{GS} - V_{TH})}{C_{gs}}$$

$$\beta = \frac{\mu \varepsilon W}{d L}$$

$$f_T = \frac{1}{2\pi} \frac{\mu}{L^2} (V_{GS} - V_{TH})$$

$$C_{gs} = \varepsilon \frac{W L}{d}$$

$$f_T = \frac{1}{2\pi} \frac{1}{T_T}$$

$$\frac{1}{T_T} = \frac{\mu V_{DS}}{L^2}$$